

國立交通大學

電子工程學系電子研究所

碩士論文

應用於無線近身網路之可調式

全數位時脈產生器

**A Tunable All-Digital Clock Generator for  
Wireless Body Area Network Applications**

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中華民國九十七年八月

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# 應用於無線近身網路之可調式全數位

## 時脈產生器

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### 摘要

對於逐漸受到重視的無線近身網路來說，高可靠度、可攜式與低製造成本的需求成為近年來最重要的研究主題之一。準確無誤地偵測人體生醫資訊，並且以有限的功率消耗加以傳輸訊號是無線近身網路的主要訴求。而在微小的感測貼片上做系統整合則是相當大的挑戰。

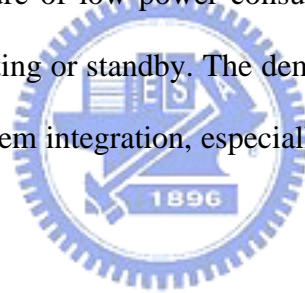
本篇論文將會針對應用於無線近身網路的時脈產生器做介紹，並以高可靠度、低功耗、低面積的觀點來設計一個可調式全數位時脈產生器。藉由可調整相位及頻率的時脈產生器與動態取樣相位頻率調整技術搭配，可在傳輸的封包錯誤率達到 1 % 時，使整體效能僅有 0.25 dB 損耗，同時並降低接收端的類比轉數位電路功耗達 46 %。而為了更進一步降低前述時脈產生器的功率消耗，本篇論文也提出一種應用遲滯電路來設計數位控制振盪器的方法，所設計的 5 MHz 數位振盪器，其最小解析度可達 0.78 ps，功率消耗僅為 2.6  $\mu$ W。在本篇論文的最後將會介紹一種可容忍製程、電壓、溫度飄移的全數位時脈產生器來當作可調式全數位時脈產生器的訊號源，其功率消耗為 343  $\mu$ W、頻率誤差最大為 0.002 %，可搭配頻率控制電路來取代傳統的石英振盪器。而以上所述的可調式全數位時脈產生器共可在無線感測端降低 89.8 % 與 88.1 % 的功率與面積消耗，使其達成在無線近身網路上高可靠度、可攜式與低製造成本的需求。

# A Tunable All-Digital Clock Generator for Wireless Body Area Network Applications

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## ABSTRACT

For wireless body area network applications, the reliability, portability and cost are the significant studies in the recent years. In order to accurately monitor the biomedical signals without interference, system reliability is the challenge. For battery limited applications, the feature of low power consumption is undoubtedly required whenever the system is operating or standby. The demand of small size in sensor tags increases the difficulty in system integration, especially within a common used quartz crystal oscillator.



In this thesis, we propose an all-digital tunable clock generator for wireless body area network applications. For 46 % ADC power reduction and only 0.25 dB SNR loss at PER=1 %, a phase-frequency tunable clock generator is applied with dynamic phase-frequency recovery technologies. So as to reduce power consumption on the always-on clock generator, a hysteresis-delay-cell-based digitally controlled oscillator is introduced, which has 0.78 ps delay resolution and consumes 2.6  $\mu$ W at 5 MHz. Finally, an all-digital and cell-based PVT tolerance clock generator is described for replacing the reference quartz crystal oscillator. It achieves 343  $\mu$ W and 0.002 % maximum frequency offset by frequency tuning capability. The overall designs enable the power and area reduction by 89.8 % and 88.1 % in wireless sensor nodes, respectively.

# 誌謝

從大四推甄上研究所後，在 SI2 實驗室已經渡過了兩年半的日子，在這段寶貴的時間內，從實驗室獲得了不少的專業知識，才能讓我完成這份論文。在此，非常感謝我的指導老師李鎮宜教授，老師豐富的學識與切入問題的角度令我受益良多，完善的研究設備與環境，使得我的研究得以順利完成。感謝實驗室的鍾菁哲學長，解決了晶片設計流程上的問題，讓我們的晶片可以順利下線。更要感謝游瑞元學長對我研究方向不厭其煩地指引，使我能完成碩士學業，最後感謝口試委員們的指導與寶貴的意見。



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# ***CHAPTER 1***

## ***Introduction***

### **1.1 Motivation**

For the ubiquitous personal healthcare inspection (uPHI) in wireless body area network (WBAN) applications, high reliability, low power consumption and low cost are especially required. Several wireless sensor nodes (WSN) are placed on or in human body for monitoring biomedical signals and the central processing nodes (CPN) collect the signals transmitted by WSN. The power and cost issues are emphasized on WSN because of the long-term monitoring and portability.

However, there exist some performance, power, area and cost problems on clock generator in present systems, such as ZigBee, Bluetooth, UWB, WiBoC [1] and so on. The sampling clock offset (SCO) degrades the system performance [2]. The analog-to-digital converter (ADC) circuits double receiver power at 2-times sampling rate [2]. Always-turned-on clock generator has much power dissipation compared with the baseband. The disintegrable quartz crystal oscillator occupies large area and power and needs extra board components which increase the manufacturing cost. The area and power comparison is shown in Fig. 1.1.

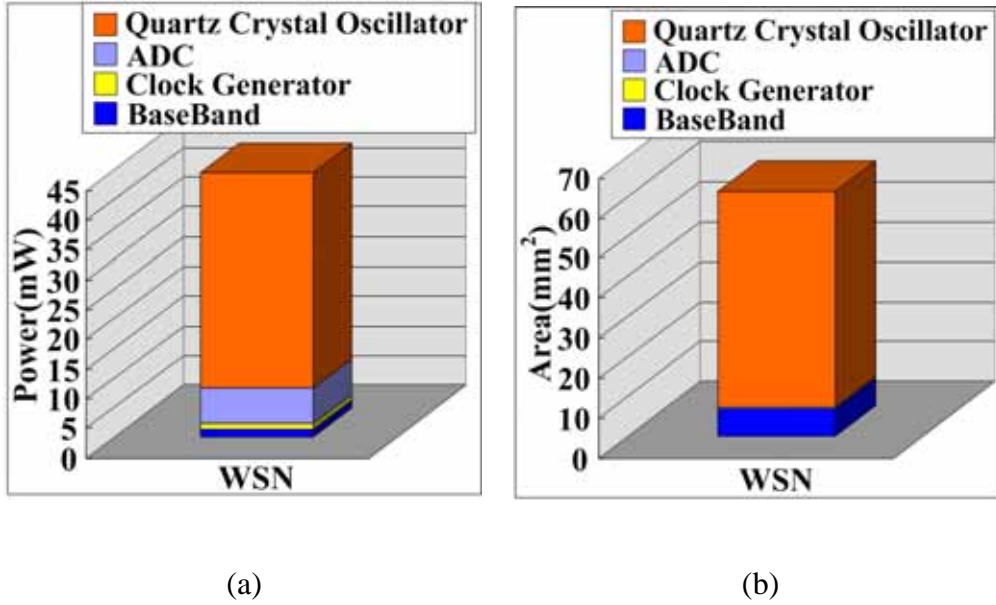


Fig. 1.1. WSN (a) power (b) area.

Dynamic phase recovery (DPR) [2] and dynamic frequency recovery (DFR) [2] have been proposed for ADC power reduction and performance improvement by the aid of a phase-frequency tunable clock generator (PFTCG) [2-3] for WBAN applications. In order to save the ADC power, DPR searches the best sampling phase in the received signal and reduces the sampling rate from Nyquist rate to the symbol rate. DFR recovers the received data and also tunes the ADC sampling frequency offset, resulting in less-interfered acquired data [2]. Fig. 1.2 and Fig. 1.3 [4] show the packet error rate (PER) and the power comparison with PFTCG by both DPR and DFR method under  $SCO = 50$  ppm, respectively. There are only 0.25 dB SNR loss at  $PER = 1\%$  and 47.7% ADC power reduction in the standard process 90 nm CMOS technology [4]. For system performance maintenance and power dissipation, the PFTCG is required in WBAN application.

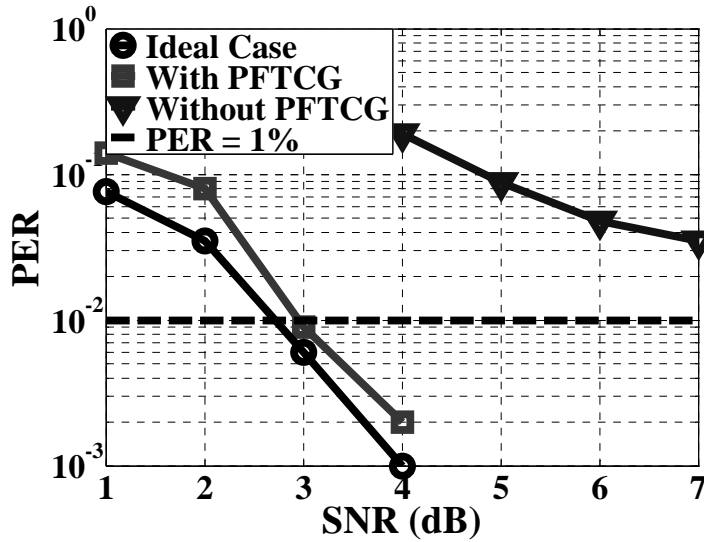


Fig. 1.2. PER without and with PFTCG. [4]

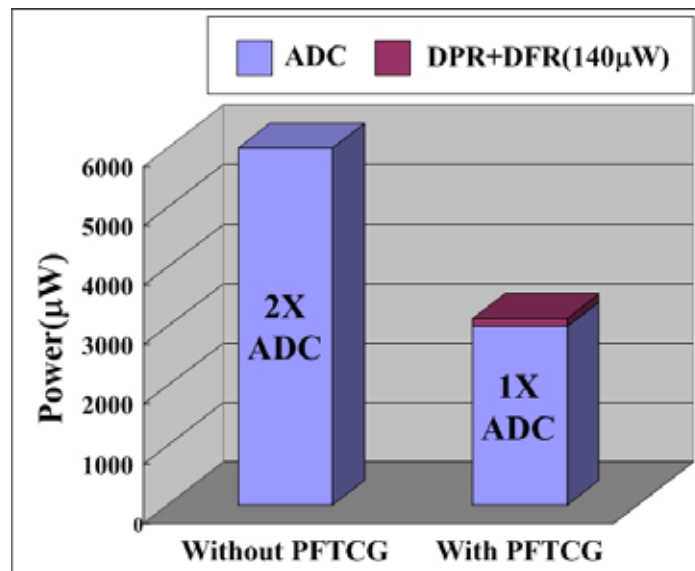


Fig. 1.3. Power consumption without and with PFTCG. [4]

All-digital clock generators have become more and more attractive in system integrations and system-on-chip (SoC) applications [5-8]. Instead of utilization passive components of voltage-controlled oscillators (VCO) in the phase-locked loops (PLL), all-digital PFTCG approach can minimize the power consumption and reduce the system turnaround time. Nevertheless, the always-turned-on PFTCG should be reduced more power in battery-limited devices in WBAN systems. Digitally

controlled oscillator (DCO) is the main module to all-digital clock generators and occupies over 50 % power dissipation [6]. The state-of-the-art DCO designs still have large power when operating frequency decreases [5-11]. Thus, this thesis attempts to propose a low power and delay tunable hysteresis delay element which is the key component in sub-10 $\mu$ W, high-resolution and wide-range DCO design.

For synchronization in PFTCG for WBAN applications, there is a reference clock source. The most common clock source is the quartz crystal oscillator which provides frequency stability regardless of process, voltage and temperature (PVT) variations. However, the quartz crystal oscillator is difficult for integration and unsuitable for small size, low cost and low power requirement in portable devices. Silicon micro-electro-mechanical systems (MEMS) [12] have been proposed as a result of lower power consumption, but they also require extra CMOS processes, wafer level packaging technologies and long manufacturing duration.

Ring oscillator based clock generator is proposed by [13] which makes use of a band-gap voltage regulator, temperature and process compensation circuits and a comparator. It accomplishes low cost demand and overcomes PVT variations, but the power dissipation is still a problem resulted from operational amplifier in band-gap regulator and comparator. Moreover, the PVT variation would have a greater effect upon stability and reliability when the process technique shrinks to nanometer scale instead of 0.25  $\mu$ m process as [13]. Fig. 1.4 shows the frequency variation of a 5 MHz standard-cell-based ring oscillator under different PVT conditions in 90 nm CMOS technology. In worst case, the frequency would vary almost  $\pm 60$  % due to different PVT condition corners. In this thesis, we propose a low cost, low power and portable PVT tolerance clock generator with frequency tuning capability in deep sub-micron CMOS process for frequency stability.

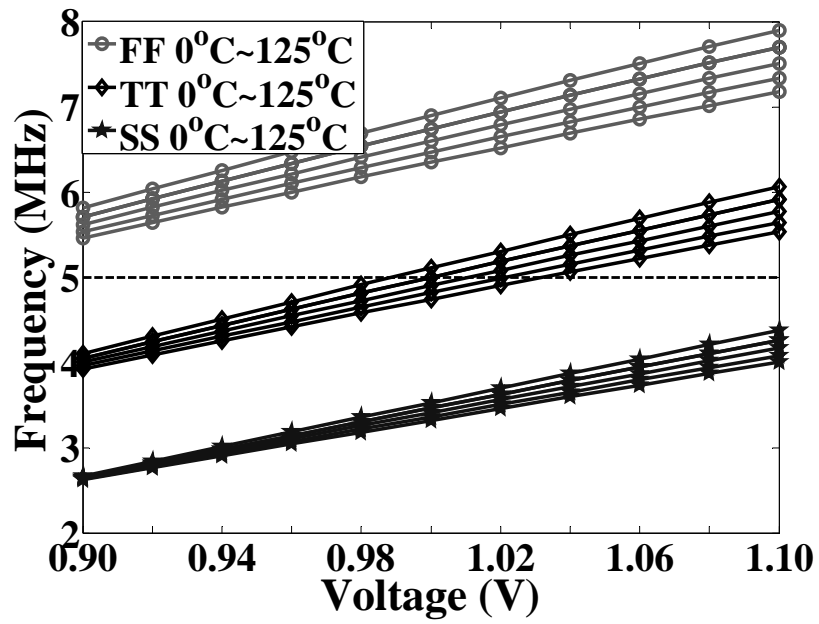


Fig. 1.4. PVT variations of ring oscillator under 90 nm process.

## 1.2 Organization

The rest of this thesis is organized as follows. At first, the all-digital PFTCG is described in Chapter 2. Then, we propose a low power delay tunable hysteresis delay cell (HDC) for DCO design in Chapter 3. Chapter 4 presents a PVT tolerance clock generator. Finally, Chapter 5 summarizes our work and discusses some design topics in the future.

## ***CHAPTER 2***

### ***Phase-Frequency Tunable Clock***

#### ***Generator***

As shown in Chapter 1, the PFTCG is used for DPR and DFR [2] to change the generated clock phase and frequency in some response time. Traditional PLLs, designed by analog approaches, are composed of phase frequency detector (PFD), charge pump (CP) circuits, loop filter (LF), VCO and frequency divider. The analog-based PLLs have more difficulty in tradeoffs among gain, supply voltage and frequency range of VCO designs in more advanced process technology. The large capacitance of LF increases chip area, but the off-chip capacitance consumes much power. Furthermore, the serious leakage current problem to CP circuits in deep sub-micron technology also dominates overall power dissipation.

On the contrary, the advantages of all digital approach, like all-digital phase-locked loop (ADPLL) [5-8], all-digital delay-locked loop (ADDLL) [14] or all-digital multi-phase clock generators (ADMCG) [15], are short lock-in time, low design complexity for voltage scaling and power minimization, and easily integration in SoC applications. Therefore, the PFTCG is proposed in all-digital scheme for



power reduction and performance improvement by the clock phase and frequency adjustments.

## 2.1 System Overview

The overall dynamic phase-frequency recovery [2] block diagram with the proposed all-digital PFTCG is shown in Fig. 2.1 [3]. The signals are transmitted with the channel noise and down-converted in the receiver side. Then, the received signals are sampled by symbol period with initial timing offset  $\varepsilon$ . After timing synchronization composed of packet detection and boundary detection blocks, the timing error detector (TED) starts maximum absolute-squared-sum (MASS) search [2] of the initial preamble. Afterward, the TED calculates the absolute-squared-sum with different sampling phase  $\hat{\varepsilon}$  provided by the PFTCG. And then, the PFTCG selects the optimal sampling phase that results in MASS.

Although TED adjusts the sampling clock phase, the drift amount due to sampling clock frequency offset  $\xi$  still increases. The frequency error detector (FED) estimates the sampling clock frequency offset after the fast Fourier transformation (FFT) by least squares (LS) algorithm [16]. The estimated sampling clock frequency offset  $\hat{\xi}$  is also sent to the PFTCG for tuning sampling frequency. To summarize, the ADC sampling clock is controlled by PFTCG with the estimated sampling phase offset  $\hat{\varepsilon}$  and sampling frequency offset  $\hat{\xi}$ .

The phase-selection capability of PFTCG enables the receiver to sample incoming signals at better instances without increasing sampling frequency, and the frequency fine-tuning capability reduces the SCO between the transmitter and

receiver for better PER performance. The design specification of PFTCG is listed in Table 2.1, including 5 MHz reference clock source and 5 MHz target output with 8 phases and  $\pm 150$  ppm frequency tuning range centered at 5 MHz.

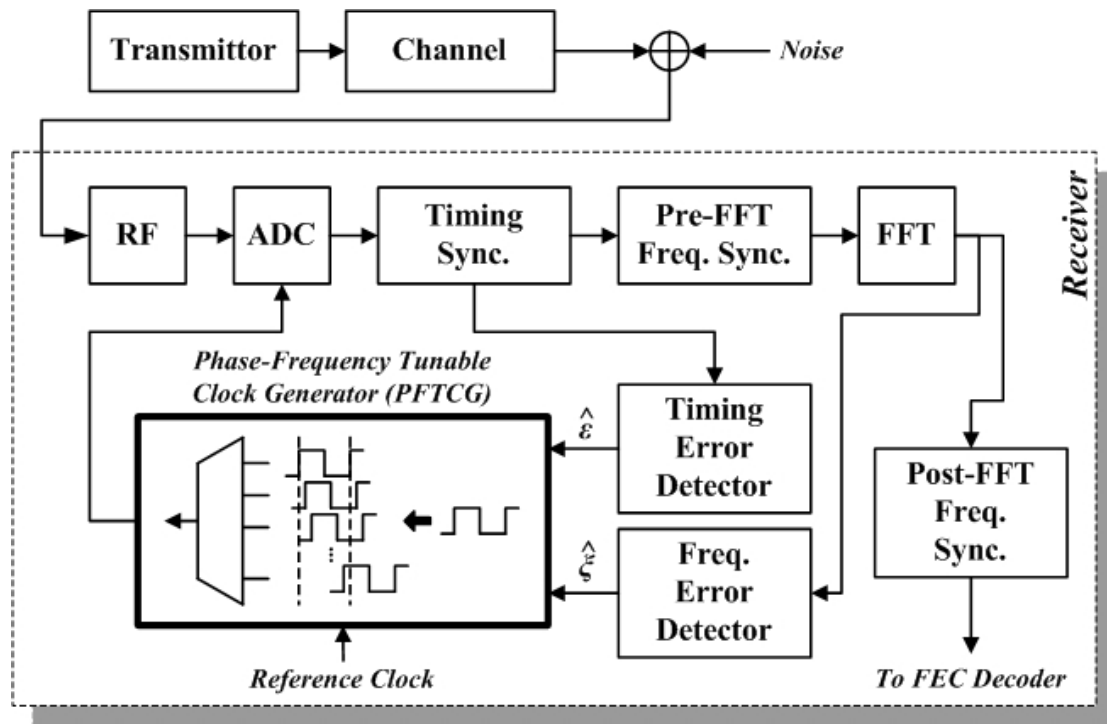


Fig. 2.1. Block diagram of the system operation with all-digital PFTCG.

Table 2.1. Specification of PFTCG.

Reference Clock Source	5 MHz
Output Clock	5 MHz
Phase Number	8
Frequency Tuning Range	$\pm 150$ ppm (@5MHz)

## 2.2 Architecture

The proposed all-digital and cell-based PFTCG architecture is shown in Fig. 2.2. There are four major blocks in the PFTCG, namely phase frequency detector (PFD), multi-phase digitally controlled oscillator (DCO), PFTCG controller, and glitch-free clock multiplexer (GFCMUX).

The reference clock ( $REF\_CLK$ ) is generated at 5 MHz by the small and highly integrated circuits which are described in Chapter 4. In the locking loop, the PFD detects the difference of frequency and phase between the reference clock ( $REF\_CLK$ ) and the DCO output ( $Phase0$ ). Then, it generates an up ( $UP$ ) and down ( $DOWN$ ) signal to indicate that the controller adjusts DCO control code ( $DCO\_CODE$ ) to speed up or slow down the DCO, respectively. The updated DCO control code can provide multi-phase DCO to generate eight phases clock (from  $PHASE0$  to  $PHASE7$ ) with equal spaced by the extracted DCO delay path. The glitch-free clock multiplexer receives the estimated sampling phase offset  $\hat{\varepsilon}$  from TED and selects the optimal sampling phase from  $PHASE0 \sim PHASE7$ . The FED delivers the estimated sampling frequency offset  $\hat{\xi}$  to PFTCG controller and slightly tunes the sampling frequency by  $DCO\_CODE$ .

According to the developed algorithm [5], the whole all-digital PFTCG operation mechanism is illustrated in Fig. 2.3. After the system reset, the all-digital PFTCG enters to a phase and frequency tracking state. The controller sets the DCO at the middle of delay path. The DCO initial search step is  $n/4$ , where  $n$  is the number of frequencies provided by the DCO. While the PFD detects from lead to lag, the search step is divided by two, and vice versa [5]. When a new DCO code is calculated, the

present DCO and PFD control signals are first cleared and then updated to the latest DCO code. To clear DCO prevents from glitches which result from directly updating DCO codeword. To clear PFD keeps the coarse-tuning loop from frequency and phase divergence.

When the search step reduces to one, the frequency of DCO output clock is acquired [5]. The DCO control code would be averaged during the next cycles for tracking the output clock frequency of DCO. Then, the lock signal (*LOCK*) triggers and DCO codeword locks the output clock frequency to the desired 5 MHz. Afterwards, the phase selection state is applied to switch and search the optimal sampling phase by the aid of TED. Finally, FED would send the estimated clock frequency offset  $\hat{\xi}$  to PFTCG, resulting in the less-interfered data before system signal processing.

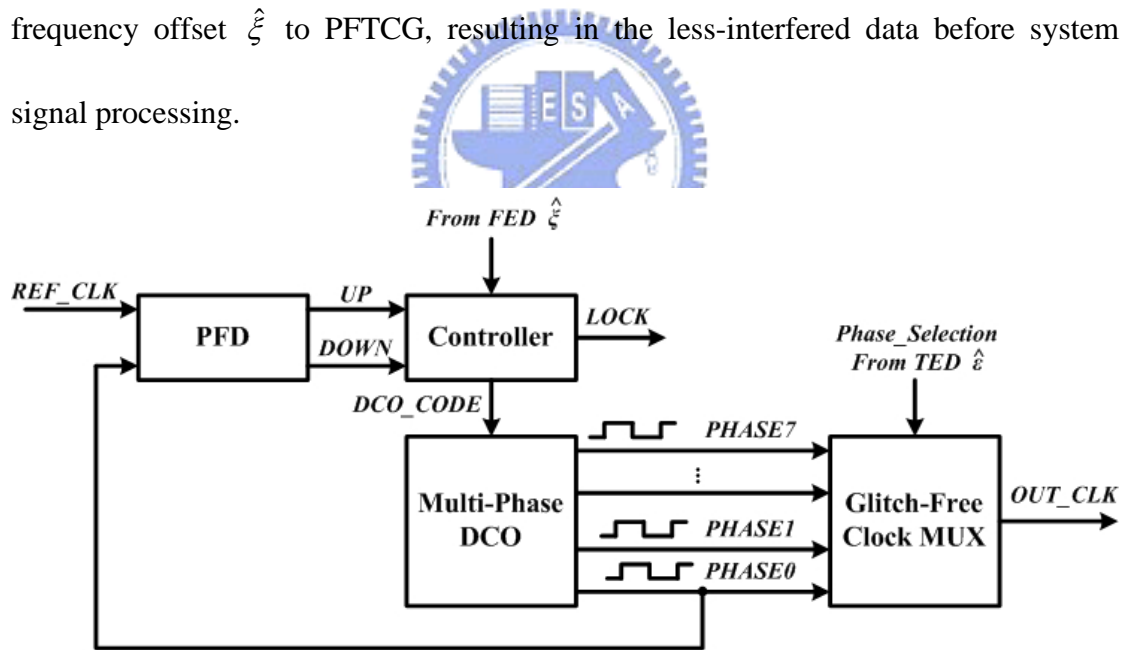


Fig. 2.2. Architecture of the proposed all-digital PFTCG.

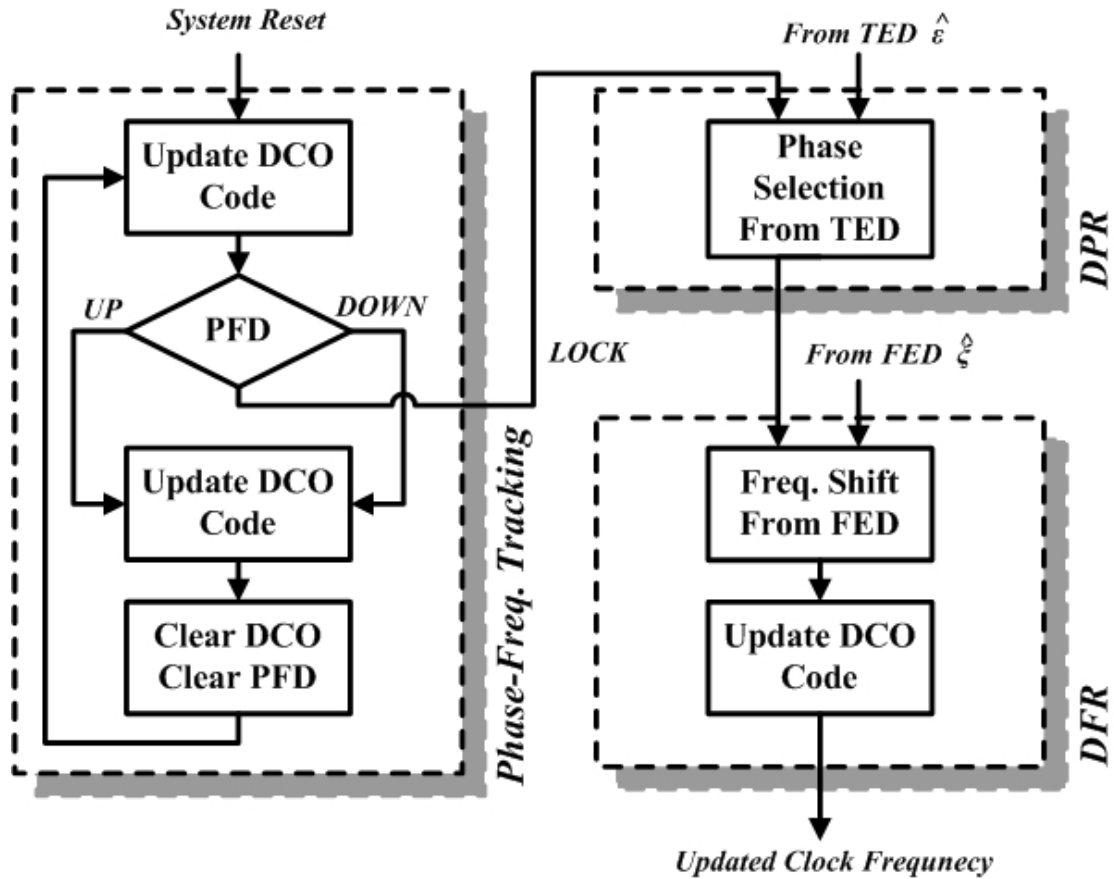


Fig. 2.3. Control mechanism of the proposed all-digital PFTCG.

## 2.3 Circuit Designs

### 2.3.1 Phase Frequency Detector

The PFD design follows the circuit topology proposed in [5] with standard cell library and the block diagram is shown in Fig. 2.4. While the feedback clock ( $PHASE0$ ) generated from DCO leads the reference clock source ( $REF\_CLK$ ), the signal  $QD$  generates a high pulse until  $REF\_CLK$  arrives the D flip-flop (DFF) and triggers for  $QU$ . The generated signal  $QU$  first goes back to the reset branch on DFF and then clears the  $QU$  and  $QD$ . At the same time,  $OUTU$  brings about a low pulse and  $OUTD$  remains high. Finally, the flags  $UP$  and  $DOWN$  will be triggered by these

signals and sent to the PFTCG controller for slowing down the DCO. On the other hand, when  $PHASE0$  lags  $REF\_CLK$ ,  $DOWN$  becomes high and  $UP$  remains low.

The dead zone problem is generally known in PFD, which is caused by the limited response time of transistors. When the pulse width of  $QU$  or  $QD$  is not long enough to turn on the following circuits, the characteristic of PFD becomes discontinuous. To minimize the dead zone, a digital pulse amplifier [5] is proposed in Fig. 2.4. It uses the cascaded two-input AND gates architecture to enlarge the pulse width of  $OUTU$  and  $OUTD$ . There is another method to eliminate the dead zone with an inserted delay buffer in the feedback path of the reset branch. The increasing response time for DFF would effectively generate a wide enough pulse width to minimize the dead zone of the PFD, thus, the following D-flip-flops can detect it. When the phase error between  $REF\_CLK$  and  $PHASE0$  is less than 5 ps, both  $UP$  and  $DOWN$  will remain in high, and no trigger signal is sent to the PFTCG controller.

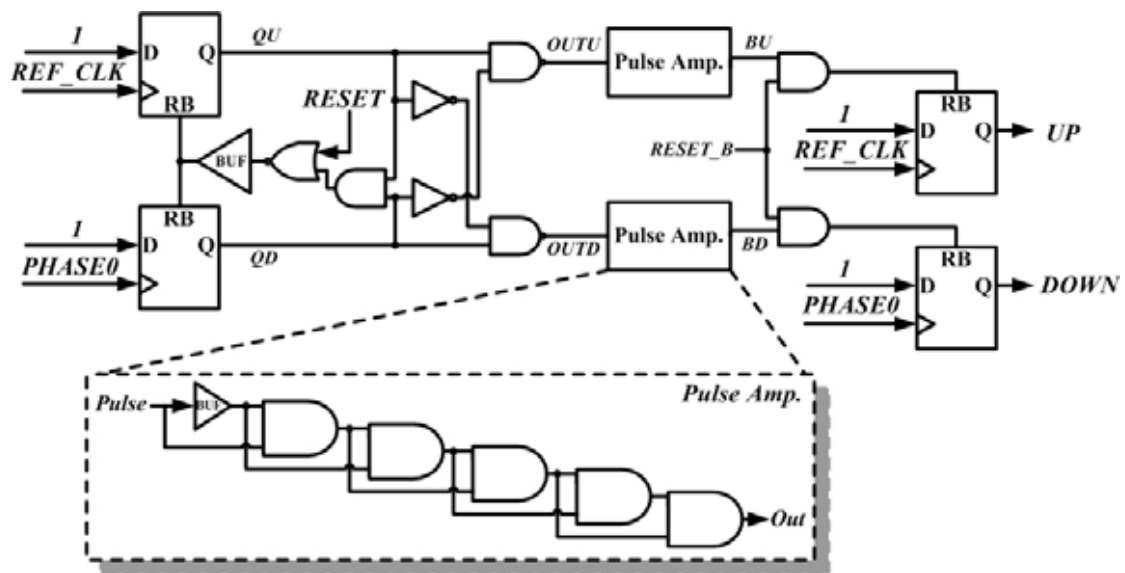


Fig. 2.4. Schematic of PFD.

### 2.3.2 Digitally Controlled Oscillator

The proposed cell-based and 8-phase 5 MHz DCO is shown in Fig. 2.5. To preserve the DCO control code resolution and wide operation range under PVT variations from several tens of nanoseconds to the ten picoseconds scale, the proposed DCO is separated into three tuning stages.

In order to provide 8 phases from the generated 5 MHz clock source, the buffers in the 1st tuning stage divide the total delay into a multiple of 50 ns in each delay segment and connect to 4 multiplexer groups. The signals, from *OUT0* to *OUT3*, are extracted from the delay chain by multiplexer groups with equal spacing. Then, they are fine-tuned individually by the following 2nd and 3rd stages and generate 8 phase clock signals by inverters (INV) and buffers (BUF).

The proposed 1st tuning stage employs cascading structure [17] with 16-to-1 path selector, as shown in Fig. 2.6, to maintain delay linearity and extend operation range easily. There are 4 bits of 1st tuning control code for the 16-to-1 path selector. The delay time difference between the two neighbor paths is determined by one 1st tuning delay cell including one buffer (BUF) and one multiplexer (MUX) as shown in Fig. 2.6. In place of the tri-state buffer architecture [5] [10-11] for path selector, the multiplexers can increase the controllable range. The summation of propagation delay from low to high ( $T_{PLH}$ ) and propagation delay from high to low ( $T_{PHL}$ ) of one 1st tuning delay cell is about 30.27 ns under PVT conditions (TT, 0.8V, 25 °C). So, the delay resolution of the outputs (*OUT0* ~ *OUT3*) is 30.27 ns when the 1st tuning control code changes by one.

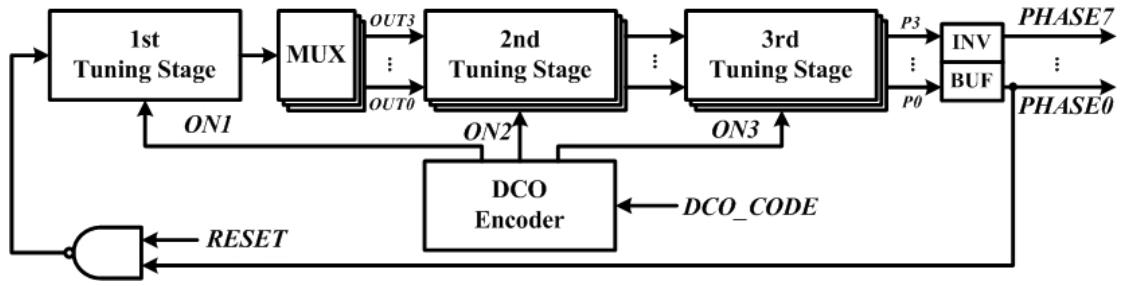


Fig. 2.5. Block diagram of DCO.

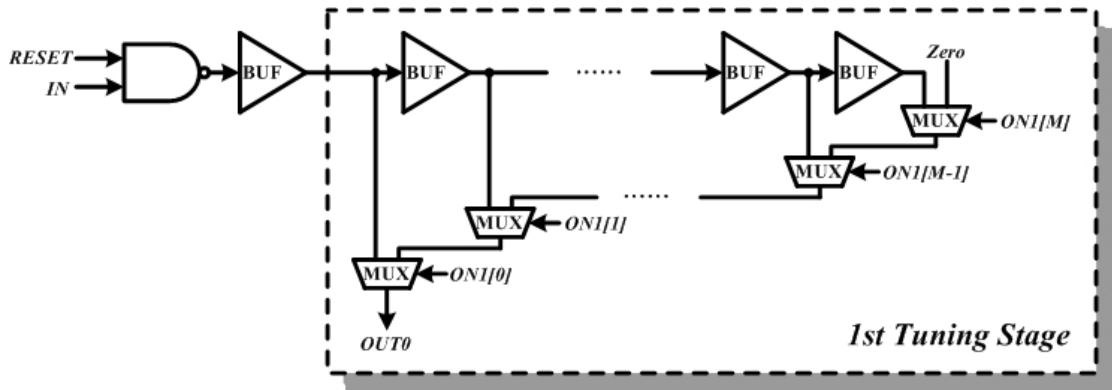


Fig. 2.6. Architecture of 1st tuning stage of DCO.

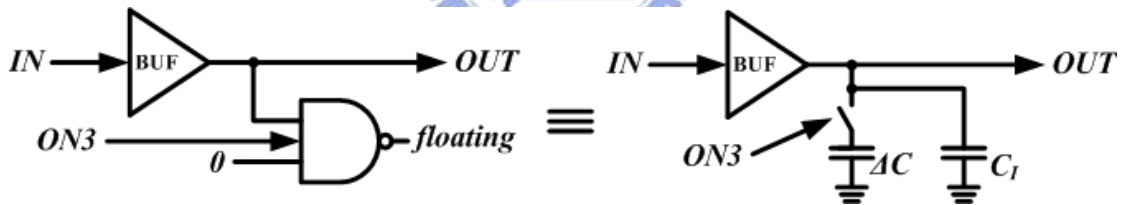


Fig. 2.7. Proposed delay cell in 3rd tuning stage [10].

Moreover, the 2nd and 3rd tuning stages are constructed after the 1st tuning stage to achieve better delay resolution of the proposed DCO. The circuit topology in the 2nd tuning stage follows the 1st stage except that the minimum delay resolution is 1.06 ns with 5 bits control code. For tracking the reference clock without the false lock in PFTCG, the controllable range of the 2nd tuning stage has to cover the delay resolution of 1st tuning stage. The principle of 3rd tuning stage design is the same as the mentioned 2nd tuning stage.



The least significant bit (LSB) resolution of the DCO can be improved to about 8.6 ps by adding 3rd tuning delay cell. The 3rd tuning stage applies the digitally-controlled varactors (DCV) [10] from cell library to accomplish the highest resolution and linearity. As shown in Fig. 2.7, there is an intrinsic capacitance ( $C_i$ ) parallel with a differential capacitance ( $\Delta C$ ) in the output node ( $OUT$ ). And the gate capacitance of 3-input NAND logic-gate is controlled by the digital code ( $ON3$ ). The other input pin is tied to zero. This 3-input NAND is selected with one input pin tied to zero to cut off the path of NMOS and PMOS from ground and voltage supply, respectively [3]. Then the on-off behavior from  $ON3$  decides if the additional loading capacitance ( $\Delta C$ ) appeared in the output node of the delay cells, resulting in the change of charge and discharge in the desired delay resolution [3].

For the  $\pm 150$  ppm frequency tuning range of design specification, the controllable range of the 3rd tuning stage has to be larger than 60 ps ( $= 2 * 200\text{ns} * 150\text{ppm}$ ). In the proposed DCO design, the range of 3 tuning stage is at least 428.8 ps ( $= \pm 1072$  ppm) under any PVT variations. There are 7 bits digital control codes in the 3rd tuning stage. Thus, the proposed DCO has 16 ( $= 4 + 5 + 7$ ) bits for tuning. Based on all standard cells, the delay resolution and controllable range of proposed three tuning stages under PVT conditions (TT, 0.8V, 25 °C) are listed in Table 2.2. It shows that the controllable range of each stage is larger than the step of the previous stage.

By HSPICE simulation, the tolerance maximum output frequency of the proposed DCO is 6.03 MHz (165.9 ns) and the minimum output frequency of the DCO is 4.48 MHz (223.0 ns) under PVT corners (SS, 0.72V, 125 °C) ~ (FF, 1.1V, 0 °C). As a result, total power consumption of the proposed DCO is 90.3  $\mu$ W and 53.7

$\mu$ W under 1.0 V and scaled 0.8 V supply voltage, respectively, in UMC 90 nm CMOS process.

Table 2.2. Controllable range and delay resolution of DCO in PFTCG.

	1st Tuning Stage	2nd Tuning Stage	3rd Tuning Stage
Code Length (bits)	4	5	7
Range (ns)	454.05	32.9158	1.0922
Resolution (ns)	30.27	1.0618	0.0086

### 2.3.3 Glitch-Free Clock Multiplexer

As above, the proposed DCO generates 8 phase clock signals for DPR. Then, one of these 8 sources is selected by the glitch-free technique [18-19]. In general, a simple multiplexer is used to perform the selection operation. However, different arrival time of the switching signals to the conventional multiplexer results in glitches. The problem with the conventional multiplexer is that the control signal may change in any time with respect to the source clocks, which creates a potential for chopping the output clock or a glitch at the multiplexer output [19]. These glitches on the clock line would lead to the difficulty in sampling data synchronization and DPR [2].

Fig. 2.8 depicts a 2-to-1 clock switching circuits [19] that provides either of two clock signals  $CLK0$  and  $CLK1$  on a clock-distribution output  $OUT\_CLK$  without switching glitches. For the purpose of protection the high pulse of  $OUT\_CLK$  against interruption, two negative edge trigger DFF are used. As shown in Fig. 2.9, in the beginning, the selection signal ( $SELECT$ ) switches to zero, and  $d0$  turns to zero immediately. Then, at the following falling edge of  $CLK0$ , the upper DFF is triggered

and  $qb0$  feedbacks to  $d1$ . At the same time,  $OUT\_CLK$  stops the propagation from  $CLK0$ . In the end, the below DFF is triggered at the following negative edge of  $CLK1$  and  $OUT\_CLK$  switches to  $CLK1$  without glitches. These circuits also assure that the second positive edge of output signal ( $OUT\_CLK$ ) after the selection signal changes from the new clock ( $CLK1$ ).

We can extend this 2-to-1 clock switching MUX to 8 clock sources switching. And each select signal has to feedback to all sources [19]. However, the DPR method orderly switches the 8 phase clocks and chooses the optimal phase by MASS search algorithm in DPR. So, we can modify the extend architecture to reduce the redundant circuits. The proposed 8-to-1 glitch-free clock MUX has not connect all feedback signals of DFF output ( $qb[0] \sim qb[7]$ ) to select signals ( $SELECTION[0] \sim SELECTION[7]$ ), as shown in Fig. 2.10. The phase selection signal ( $P[0:2]$ ) controlled by TED transfers to  $SELECTION[0:7]$  by a decoder.

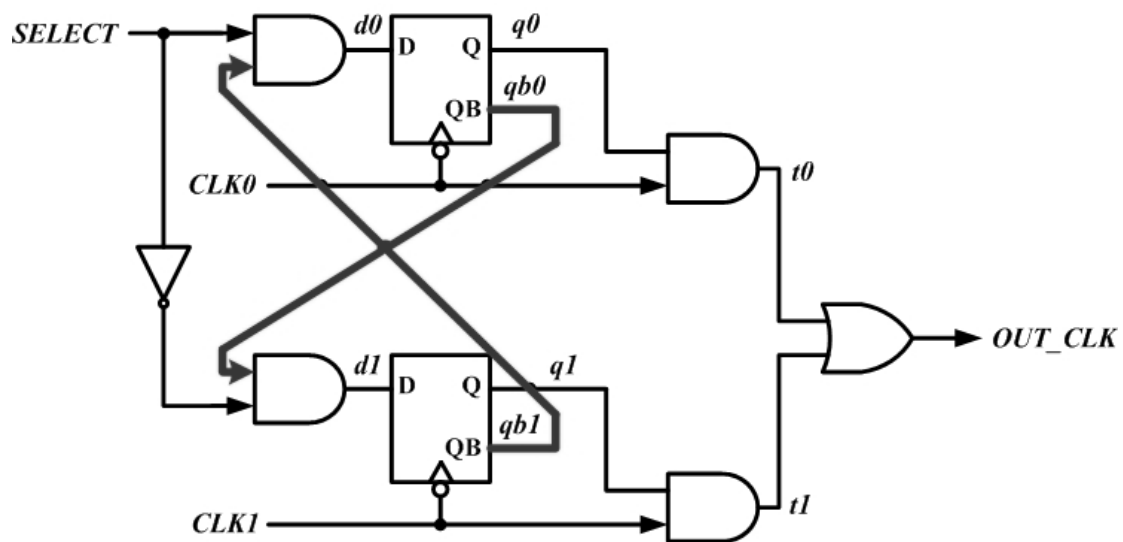


Fig. 2.8. Schematic of 2-to-1 glitch-free clock MUX [19].

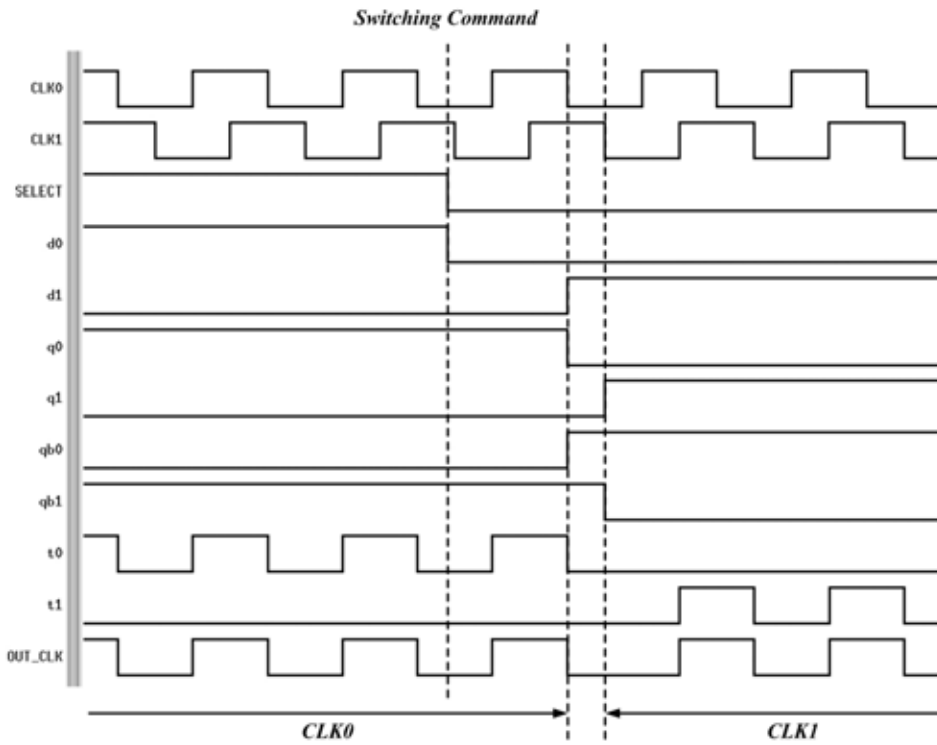


Fig. 2.9. Simulated waveforms of the 2-to-1 glitch-free MUX.

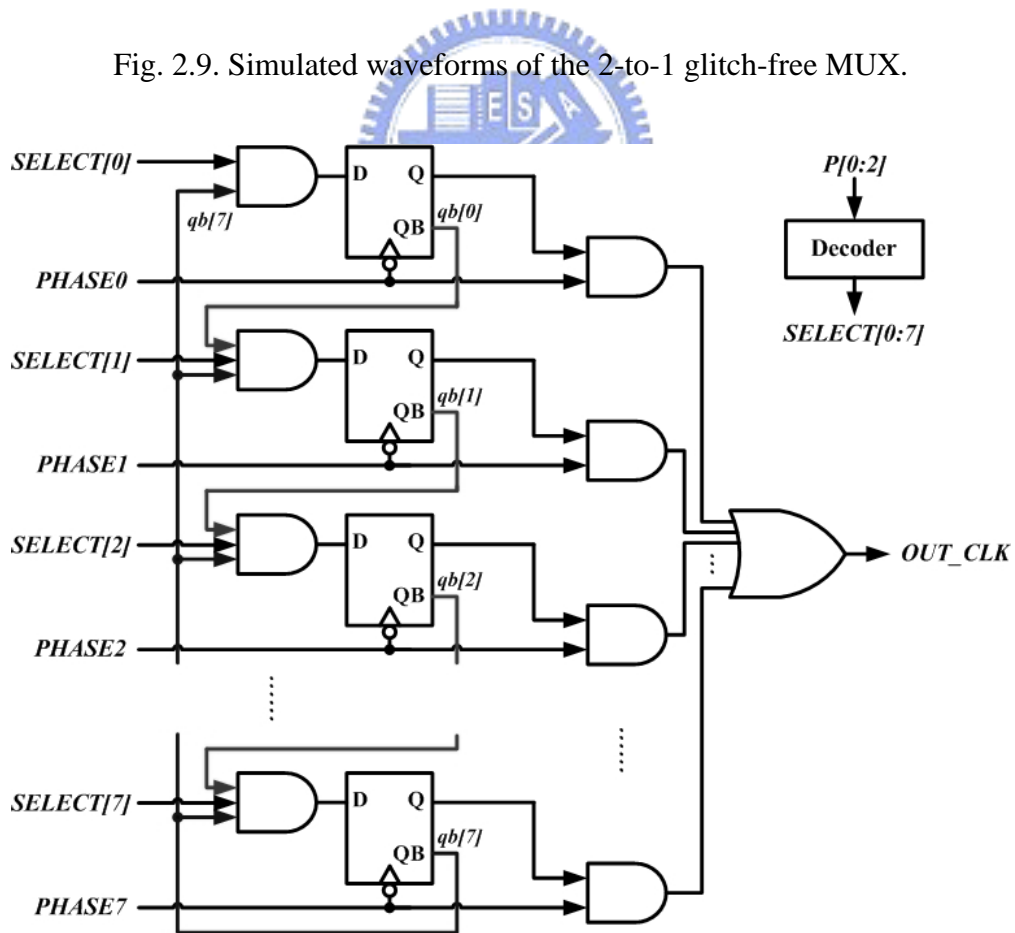


Fig. 2.10. Proposed 8-to-1 glitch-free clock MUX for DPR.

## 2.4 Simulation Result

Fig. 2.11 shows the transient response of the proposed PFTCG operation scenario, where the reference clock ( $REF\_CLK$ ) is 5 MHz. When the  $RESET$  is triggered, the PFTCG starts to track the frequency and phase of reference clock. The DCO control codeword ( $DCO\_CODE[15:0]$ ) is converged to desired 5 MHz until the  $LOCK$  signal is triggered. By using an adaptive search step in frequency acquisition as described in Section 2.2, the PFTCG can finish the tracking state in 128 ( $= 4 * 2 * \log(2^{16})$ ) reference clock cycles in this worst case. During this tracking time, it is found that the  $CLEAR\_DCO$  signal is sent frequently to update the DCO loop to a new delay path to avoid the glitches in the loop.

Then, the phase selection signal  $P[2:0]$  controls the glitch-free clock multiplexer to switch the output phase ( $PHASE[7:0]$ ) in order when the PFTCG is required to change the output clock phase to the optimal phase by TED. After the searching of phases, output clock ( $OUT$ ) is fixed its sampling phase by the estimated sampling phase offset  $\hat{\epsilon}$ . The frequency tuning control signal  $\hat{\xi}$  (corresponding to the signals  $TUNE\_VALID$  and  $TUNE\_CODE$ ) from FED is sent for fine-tuning the frequency of output clock.

In Fig. 2.12, there are 8 even-spaced clock waveforms in the switching phase state. The phase of output clock is switched from  $PHASE7$  to  $PHASE2$ . Each pair of waveforms has about 25 ns delay. The percentage between each phase slot is 10 %, 10 %, 10 %, 12 %, 14 %, 14 %, 14 % and 15 % of one period from  $PHASE0$  to  $PHASE7$ , respectively.

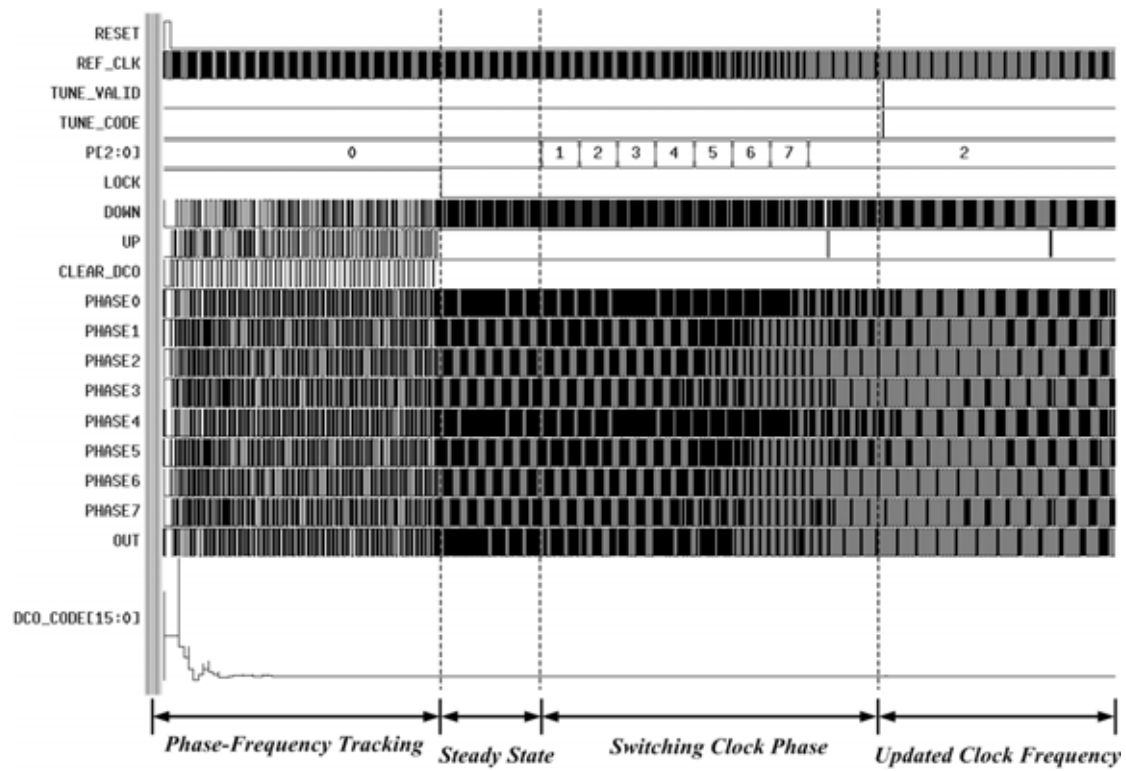


Fig. 2.11. Simulated waveforms of PFTCG operation scenario.

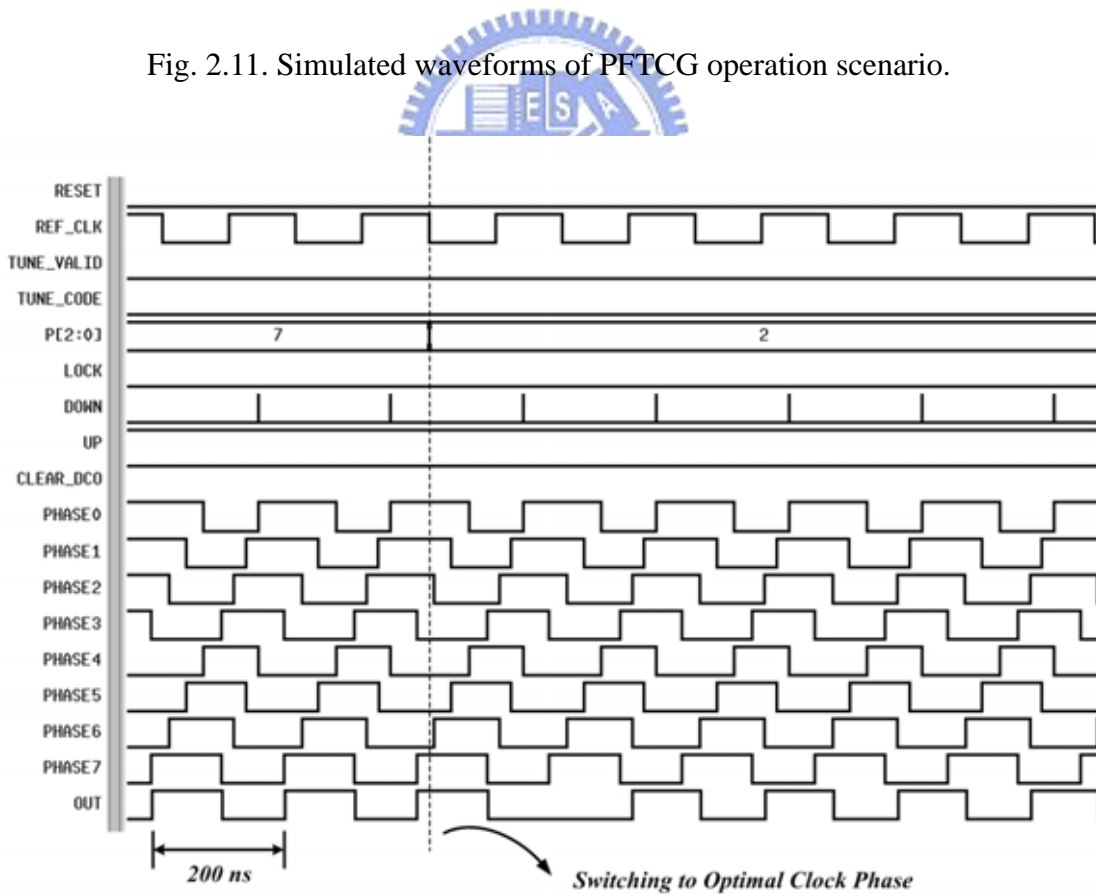


Fig. 2.12. Simulated multi-phase waveforms of PFTCG.

## 2.5 Implementation and Measurement Result

We summarize the PFTCG hardware information in Table 2.3. The PFTCG is an always-on building block that continuously consumes both dynamic and static power. Therefore, it is implemented in the UMC standard process 90 nm high threshold voltage (SPHVT) CMOS technology for static current saving. The frequency of reference clock source is 5 MHz. The generated phase-frequency tunable output clock has 8 phases at 5 MHz. The delay cell resolutions of 1st ~ 3rd tuning stage in the DCO circuits are 30.27 ns, 1.06 ns, and 8.6 ps, respectively. Fig. 2.13 shows the area distribution of all-digital PFTCG. The DCO and controller almost occupy overall area.

Table 2.3. The proposed PFTCG hardware profile.

Technology	Standard 90 nm SPHVT CMOS
Target Frequency	5 MHz
Phase Number	8
1st Tuning Stage Resolution	30.27 ns
2nd Tuning Stage Resolution	1.06 ns
3rd Tuning Stage Resolution	8.6 ps
Freq. Tuning Range	$\pm 1072$ ppm(@5MHz)
Core Area	$125 \mu\text{m} \times 252 \mu\text{m}$

The PFTCG designed layout view is shown in Fig. 2.14. In the area of this PFTCG, the main part is the DCO circuits from the delay cells to constitute the 25 ns delay in each delay phase. In the rest of the area, it mainly comes from the control circuits because the long delay line has multiple of delay stage to control and it



requires lots of circuits to decode the control signals. This PFTCG is integrated in a test system [21], dual-mode (MT-CDMA & OFDM) baseband transceiver, for system verification with the PFTCG area  $125 \mu\text{m} \times 252 \mu\text{m}$ , where the chip microphoto and layout of the PFTCG is shown in Fig. 2.15.

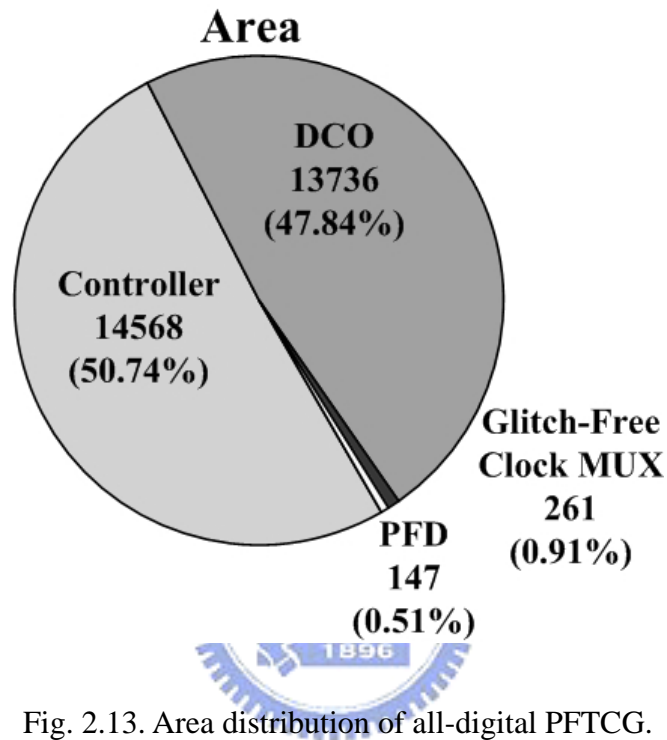


Fig. 2.13. Area distribution of all-digital PFTCG.

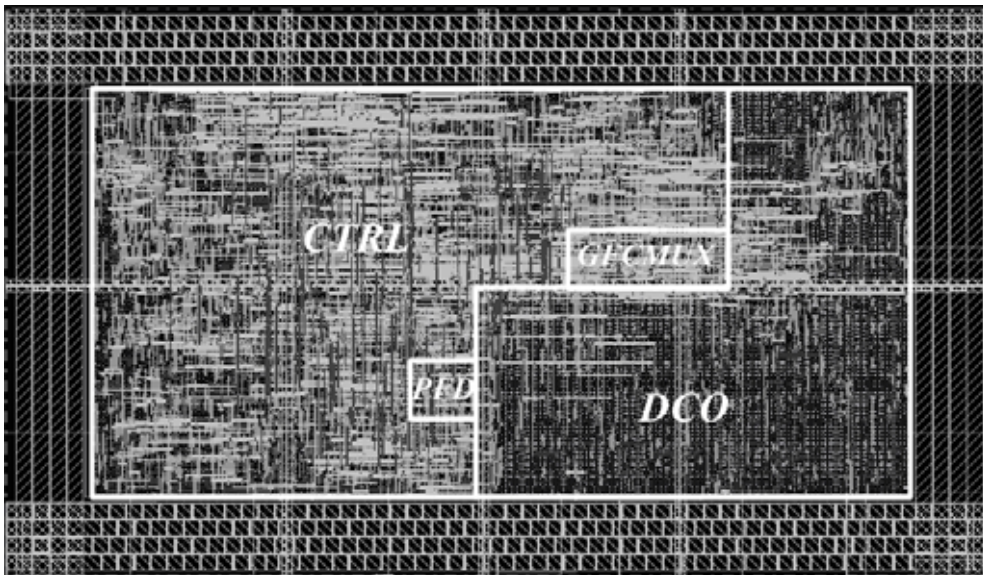


Fig. 2.14. Layout of the proposed PFTCG.



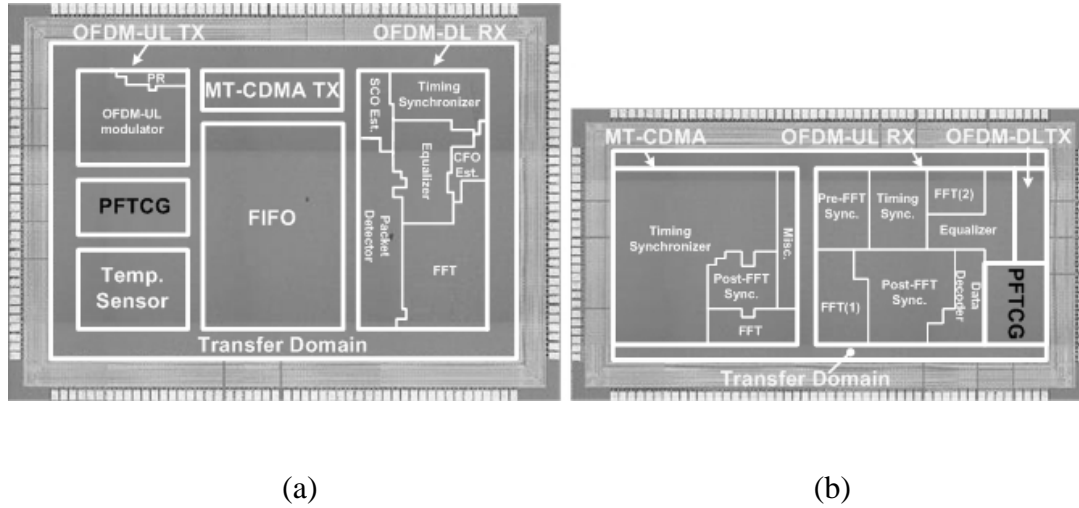


Fig. 2.15. Micro chip photo (a) WSN (b) CPN. [21]

Fig. 2.16 shows the measured output waveform of PFTCG using LeCroy LC584A. There four phase outputs (*PHASE0*, *PHASE2*, *PHASE4* and *PHASE6*) at Channels 1, 2, 3 and 4. Both peak-to-peak phase jitter and maximum root-mean-square (RMS) jitter at 5 MHz are 287 and 640 ps over 15032 sweeps, respectively. By using a current-meter with 100 pA resolution at 1V/25 (supply of I/O pad is 2.5 V), the measured power consumptions are 145.8  $\mu$ W and 95.4  $\mu$ W at 5 MHz with 1.0 V and 0.8 V supply voltage, respectively.

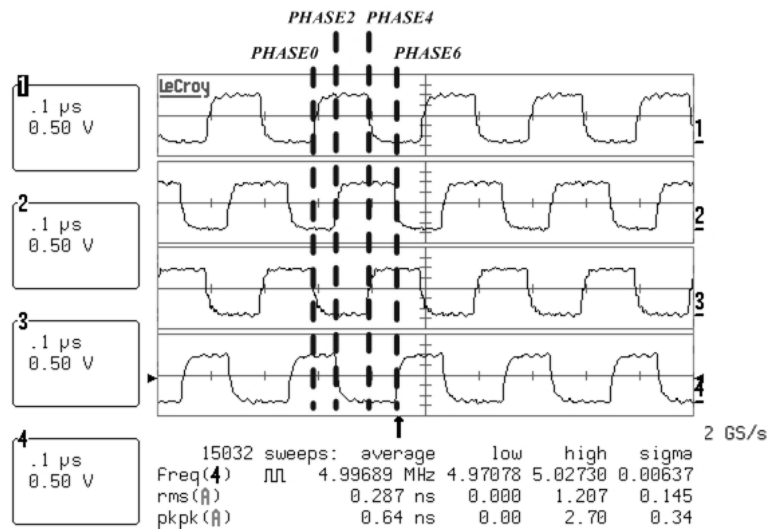


Fig. 2.16. Measurement result of PFTCG.

## 2.6 Summary

An all-digital and cell-based clock generator is designed to enable the clock phase and frequency tuning dynamically during the wireless communications system in operation. The proposed all-digital PFTCG provides 8 clock phases for selection and enables the ADC sampling signals with lower frequency and better sampling phase, resulting in lower power dissipation. The PFTCG also achieves  $\pm 1072$  ppm frequency tuning range centered at 5 MHz under any PVT variations, leading to high performance against SCO. Comparing with the no sampling offset case, there is only 0.25 dB SNR loss when PER = 1 % as shown in Fig. 1.2 [4]. Hardware is measured with 145.8  $\mu$ W and 95.4  $\mu$ W at 5 MHz with 1.0 V and 0.8 V supply in the standard process 90 nm CMOS technology. The overall power comparison is shown in Fig. 2.17. There is 46.1 % ADC power reduction included the overhead of DPR, DFR and PFTCG. Therefore, this proposed PFTCG enables the robust and high performance in SoC design for WBAN applications.

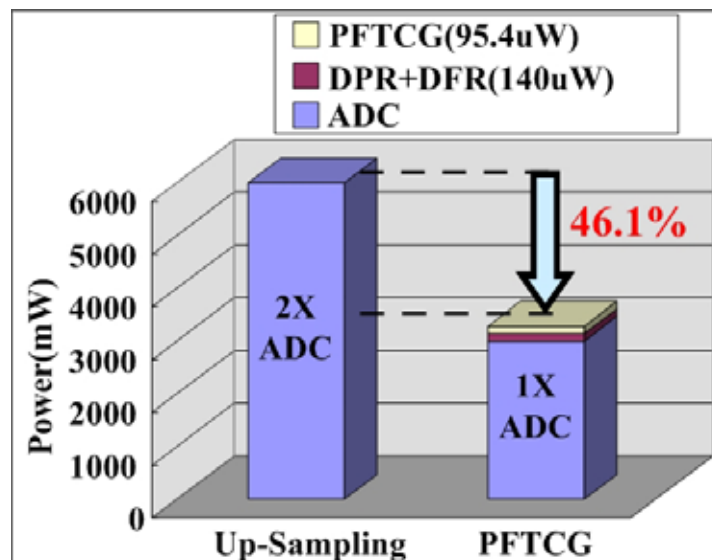


Fig. 2.17. ADC power comparison.

## ***CHAPTER 3***

# ***Hysteresis-Delay-Cell-Based Digitally Controlled Oscillator***

To meet power-critical or battery-less systems for WBAN application, a low power DCO is required in always-on clock generator. But, in most state-of-the-art DCO circuits to ADPLL [5-8], ADDLL [14] or ADMCG [15] circuits, the aspect of low power and fine delay resolution in low frequency application are not considered together. General techniques have been proposed to operate in low frequency, which is used by frequency divider circuits or long delay lines in DCO. In the frequency divider circuits approach, however, the original delay resolution of the divided signal would be damaged by frequency divider. Although the fine delay resolution can be achieved by the long delay line in DCO, the area and power dissipation also increases due to the cascading buffers in the long delay line [3]. The power consumption and delay resolution are always a trade-off in DCO design.

The power of the previous proposed DCO in Chapter 2 occupies 75 % power consumption of all-digital PFTCG under 1.0 V. This DCO power is dominated by the cascading buffers (BUF) [17] and DCV [10] as shown in Fig. 2.6 and Fig. 2.7,

respectively. Each BUF is composed of a multiple of inverters for achieving 200 ns (5 MHz) delay values. But, the long cascading inverter chains waste much power with the switching transistors for the desired long delay as shown in Fig. 3.1. The poor energy and area efficiency in the cascading inverter chains is the major drawback for the low frequency application DCO design.

The state-of-the-art DCO has been proposed in several architectures. For low power scheme, a 140  $\mu$ W DCO has been proposed in [11]. When the DCO delay line selects a shorter delay path to provide higher operation frequency, some rest delay cells will not be used. These disabled delay cells still consumes extra power in DCO [11]. In order to disable the redundant delay cells in the operating DCO for power reduction, these delay cells are isolated from the delay loop in DCO [11]. Then, the DCO power is only related to the essential characteristic of the working cells.

But, for further power reduction in DCO, there is a design challenge to decrease the power consumption in the cascading standard cells. Table 3.1 shows the delay value and power consumption of UMC 90 nm SPHVT standard cells. The cell delay is given by

$$T_D = T_{PHL} + T_{PLH} \quad (3-1)$$

where  $T_{PHL}$  and  $T_{PLH}$  is the high-to-low and low-to-high propagation delay of each cells, respectively. The simulation is under PVT conditions (TT, 1.0V, 25  $^{\circ}$ C). As the operating frequency becomes lower, the increasing power on the cascading cells would occupy higher power ratio in the DCO.

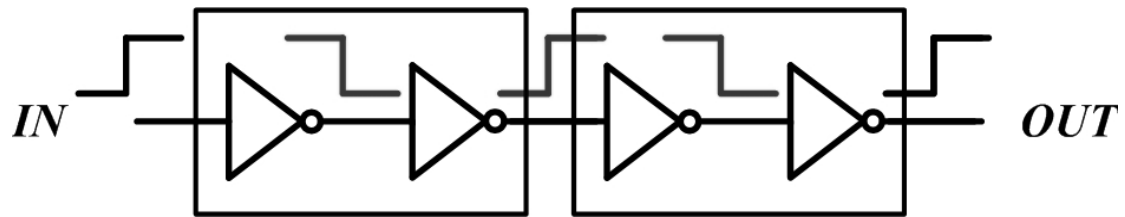


Fig. 3.1. Repeating switching through cascading inverter.

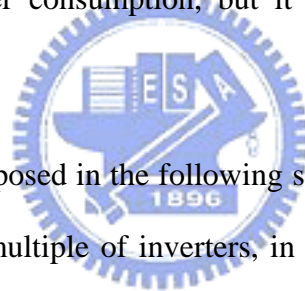
Table 3.1. Delay and power of standard cells in 90 nm technology.

	BUFM2H	BUFM4H	BUFM8H	DEL1M1H	DEL1M4H	DEL2M1H
Delay (ns)	0.100	0.095	0.090	0.223	0.199	0.344
Power ( $\mu$ W)	57.01	111.44	225.79	40.23	85.65	30.59

Furthermore, the techniques [5-11] [22] for improving the DCO resolution also affect the overall power consumption. For example, by controlling the number of the enabled tri-state buffers or tri-state inverters bank, driving capability modulation (DCM) technique changes the transistor driving capability on a fixed capacitance loading [6]. Nevertheless, DCM has the disadvantages of poor delay resolution, nonlinearity, large power dissipation and large area. Although the digitally controlled LC oscillator provides high tuning range and good stability [22], it requires dedicated circuit layout design and occupies large power consumption and area, which is composed of a parasitic capacitance tank. Additionally, the DCO with current-starved delay element [9] can change the delay value with the different controlling current and achieve high resolution, but the static current source consumes much static power. In contrast with [9], the delay cell is constructed from transmission gates by the

equivalent channel resistance in the charge and discharge path [8]. It achieves high delay resolution, but the power dissipation is still unacceptable.

Another delay resolution improvement technique uses different input code to control the charge path of or-and-inverter (OAI) cell shunted with tri-state inverters [5]. However, this approach also has nonlinear delay step. The other techniques [10] [20], moreover, use the shunt capacitor circuits to fine-tune the capacitance loadings and improve delay resolution and linearity. Unfortunately, DCV result in a poor performance on power consumption and area to maintain an acceptable operation range. Hysteresis delay cell (HDC) and DCV were proposed together in [7] [11], which was the first use of HDC in a DCO design. The HDC can replace many DCV cells and reduce some power consumption, but it does not possess better power feature than an inverter.



Thus, a new HDC is proposed in the following sections to generate a wide delay range equal to the one in a multiple of inverters, in a simple technology, instead of cascading lots of buffers or inverters. The proposed HDC can not only overcome the design challenge in DCO power reduction with the least area, but also achieve high delay resolution, especially in sub-100MHz DCO designs.

### 3.1 Hysteresis Delay Cell

The HDCs [23-25], or namely Schmitt triggers, were widely used in digital and analog circuits for waveform shaping under noisy environment. As shown in Fig. 3.2, the switching point of CMOS inverter circuits is fixed at the average of high level voltage and low level voltage because the PMOS and NMOS are both in the saturation region. But the output signal of HDC circuits is filtered by the high level and low level threshold voltage, donated as  $V_+$  and  $V_-$ , respectively. There exists an extra delay between the output of the inverter and HDC due to the hysteresis phenomenon.

Fig. 3.3 describes the transfer function of HDC. The Boolean logical function of HDC in Fig. 3.3 is the same as an inverter gate. In forward switching path, the voltage of output ( $V_{OUT}$ ) remains high level until the voltage of input ( $V_{IN}$ ) increases to  $V_+$ . Then, the output ties to the low voltage. Oppositely, when  $V_{IN}$  decreases to  $V_-$ ,  $V_{OUT}$  switches to the high level voltage. The hysteresis voltage width of HDC is defined as equation (3-2).

$$V_{hw} = V_+ - V_- \quad (3-2)$$

The hysteresis width presents the output from the cross-talk noise and supply noise on clock and supply power, and also increases the response time of HDC circuits. However, the feature of hysteresis, or non-sensitivity with input, can provide a long delay in place of lots of cascading inverters.

There are three common HDC in the following sections, including Rabaey [23], Dokic [24] and Sarawi [25] architecture. We attempt to analyze the power consumption and compare with the standard cells in UMC 90 nm CMOS technology.

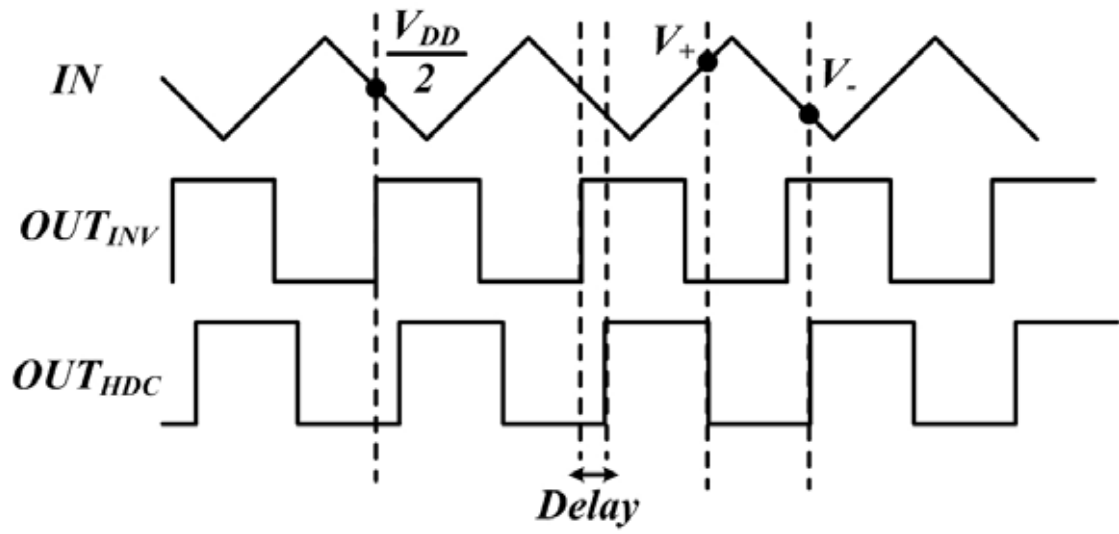


Fig. 3.2. Output signals through inverter and HDC.

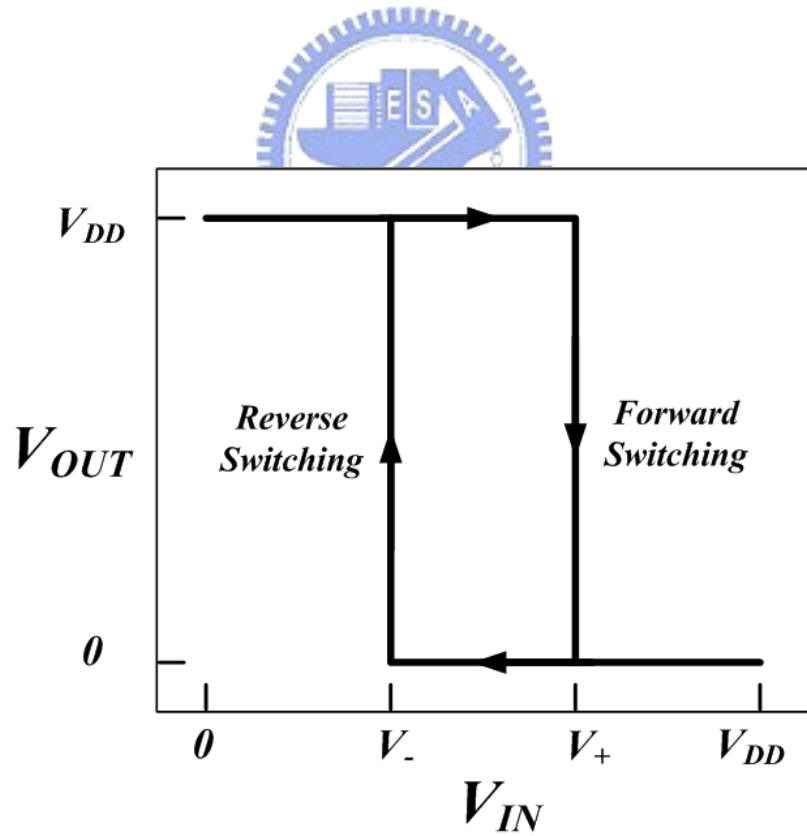


Fig. 3.3. Transfer function of HDC.



### 3.1.1 Rabaey Architecture

The HDC with Rabaey architecture was proposed as shown in Fig. 3.4 [23]. There are three inverters in this architecture. The transfer function of Rabaey's HDC is different from that in Fig. 3.3. The Boolean logic of this Rabaey architecture is the same as a buffer cell.

The static behavior of Rabaey architecture is stated as follows. In the beginning, we assume the input voltage  $V_{IN}$  is in high level voltage  $V_{DD}$  and the output voltage is tied to low. When  $V_{IN}$  decreases to a certain voltage  $V_{\cdot}$ , the  $mp3$  and  $mn4$  invert the output voltage to  $V_{DD}$ . Therefore, the output feedbacks to  $mp3$  and  $mn4$  to speed up the transition and produce a clean output signal [23]. The low level switching point  $V_{\cdot}$  is determined by the transistor  $mp1$ ,  $mn1$  and  $mn2$ . The analysis as forward switching is similar to the above. However, Rabaey HDC consumes large power dissipation due to the short current path.

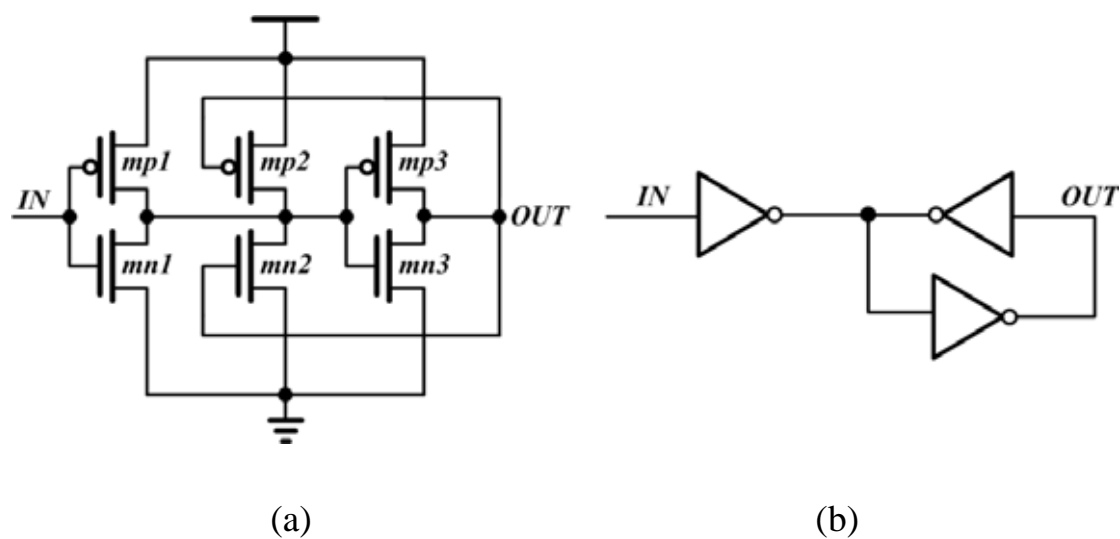


Fig. 3.4. Rabaey HDC (a) Circuits (b) Schematic.

### 3.1.2 Dokic Architecture

There is Dokic architecture of HDC as shown in Fig. 3.5 [24]. The transfer function is the same in Fig. 3.3 as well. It can be extended to a NOR and NAND type HDC. When the input voltage  $V_{IN}$  is equal to  $V_{DD}$ ,  $mp1$  and  $mp2$  are in cut off region, and  $mn1$  and  $mn2$  are turned on. So, the voltage of output  $V_{OUT}$  is equal to ground resulting  $mn3$  in cut off region and  $mp3$  in saturation region. While  $V_{IN}$  decreases to  $V_{-}$ ,  $mp1$  and  $mp3$  act as a saturated enhancement-mode inverter. Transistor  $mp2$  turns on as well, providing a charging path from  $V_{DD}$  to output. Oppositely, if  $V_{IN}$  increases to  $V_{+}$ ,  $mn1$ ,  $mn2$  and  $mn3$  are on. Then, there is a discharging path from output to ground. These obvious short current paths bring about the major power consumption in the Dokic HDC.

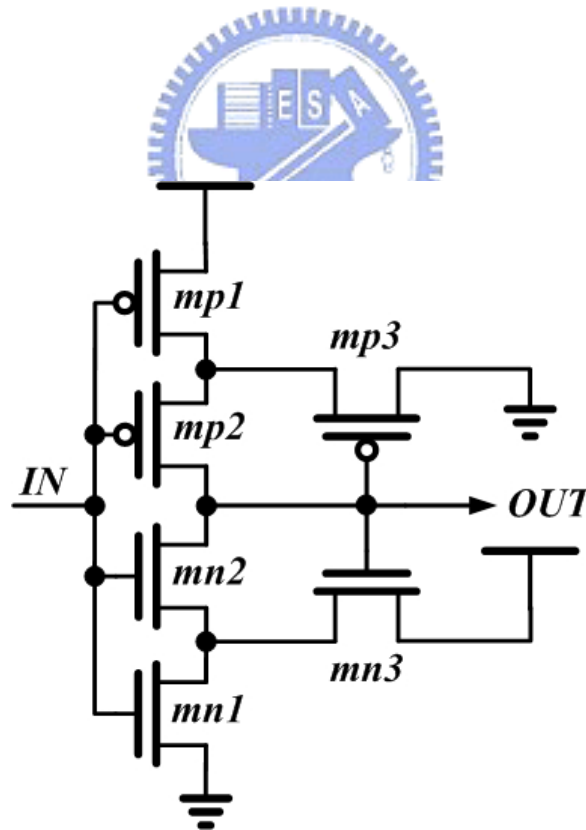


Fig. 3.5. Dokic HDC.

### 3.1.3 Sarawi Architecture

Fig. 3.6 illustrates Sarawi HDC [25] which is designed by inverter chain internally cascaded with a footer and a header. Fig. 3.3 depicts the transfer function. The operation of this HDC circuit can be described as follows. First, suppose the initial input voltage  $V_{IN}$  is  $V_{DD}$ , so that the  $mn2$  is on and the  $mp2$  is in cut off region, which implies  $mn3$  is turned off,  $mp3$  is turned on,  $mn1$  is on and  $mp1$  is off. Transistor  $mn2$  remains on and  $mp2$  remains off until  $V_{IN}$  decreases to a certain voltage  $V_-$ , at which output,  $V_{OUT}$  switches from a low to a high value. The similar behavior as forward switching with  $mp2$ ,  $mn2$  and  $mn1$  is observed as follows. When a low level voltage is applied to  $V_{IN}$ ,  $V_{OUT}$  goes to  $V_{DD}$ .  $V_{OUT}$  would switch from  $V_{DD}$  to ground until  $V_{IN}$  increases into the high level threshold voltage  $V_+$  and triggers the pull-down network. Because of the lack of directly short current path, the longer delay and less power consumption can be expected in Sarawi HDC.

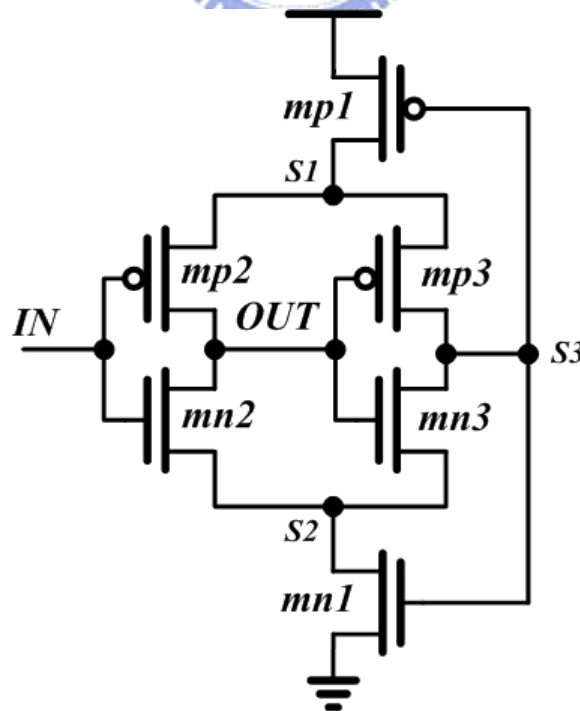


Fig. 3.6. Sarawi HDC.

### 3.1.4 Comparison

Table 3.2 lists the performance comparisons with the above HDCs and the standard cells in UMC SPHVT 90 nm CMOS technology, including BUFM2H, BUFM4H, BUFM8H, DEL1M1H, DEL1M4H and DEL2M1H. The simulation PVT condition is at typical corner case and 1.0 V supply voltage.

Table 3.2. Performance comparison with standard cells and HDCs.

	Delay (ns)	Area ( $\mu\text{m}^2$ )	Power ( $\mu\text{W}$ )	Area Efficiency ( $\text{ns}/\mu\text{m}^2$ )	Area Efficiency Normalization (%)	Energy Efficiency ( $\text{s}/\mu\text{J}$ )	Energy Efficiency Normalization (%)
BUFM2H	0.100	0.154	57.01	0.648	6.74	0.018	3.95
BUFM4H	0.095	0.307	111.44	0.308	3.20	0.009	2.02
BUFM8H	0.090	0.614	225.79	0.146	1.52	0.004	1.00
DEL1M1H	0.223	0.170	40.23	1.314	13.67	0.025	5.59
DEL1M4H	0.199	0.421	85.65	0.474	4.93	0.012	2.63
DEL2M1H	0.344	0.170	30.59	2.030	21.12	0.033	7.36
Rabaey	0.177	0.154	72.34	1.152	11.98	0.014	3.11
Dokic	0.212	0.115	31.53	1.842	19.16	0.032	7.14
<i>Sarawi</i>	<b>1.384</b>	<b>0.144</b>	<b>2.25</b>	<b>9.612</b>	<b>100</b>	<b>0.444</b>	<b>100</b>

The cell delay is the summation of high-to-low and low-to-high propagation delay, defined in equation (3-1). The area efficiency is an index of cost as (3-3), which is the delay comparison within same area. And, the energy efficiency means the inverse of transition power as (3-4). These two parameters can be regarded as a figure of merit to evaluate the performance of delay cells.

$$\text{Area Efficiency} = \frac{\text{Delay}}{\text{Area}} \quad (3-3)$$

$$\text{Energy Efficiency} = \frac{\text{Delay}}{\text{Energy}} \quad (3-4)$$

The normalization of area and energy efficiency is shown in Fig. 3.7 and Fig. 3.8, respectively.

By the simulation results, it is found that the HDCs of Rabaey and Dokic perform similar area and energy efficiency to the standard cells. But, the Sarawi architecture represents the best performance in both area and energy efficiency. That implies the Sarawi HDC can achieve the same delay by using the least area and energy compared with the other delay cells. So, we will re-analyze the Sarawi HDC in the following section and propose a new delay tunable and low power HDC for DCO resolution improvement.

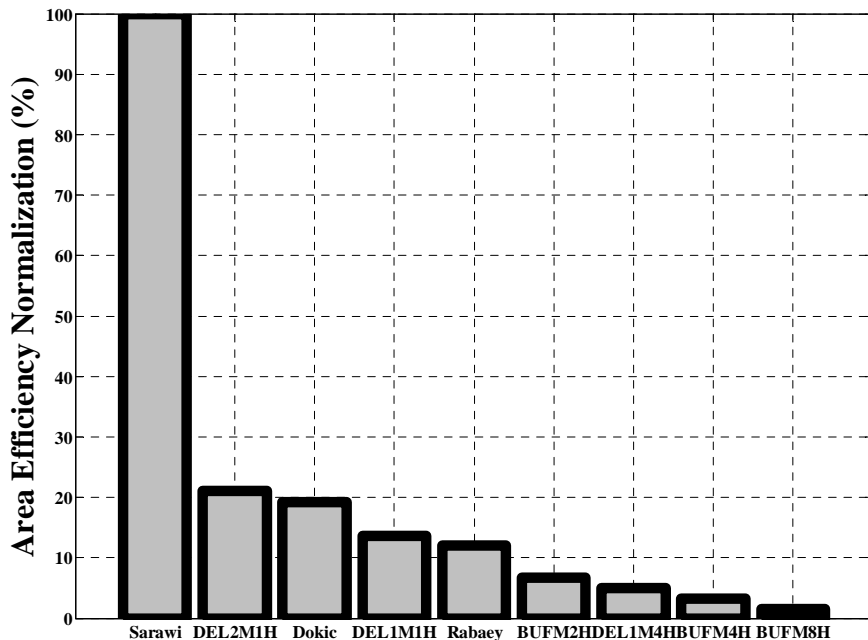


Fig. 3.7. Normalization of area efficiency with standard cells and HDCs.

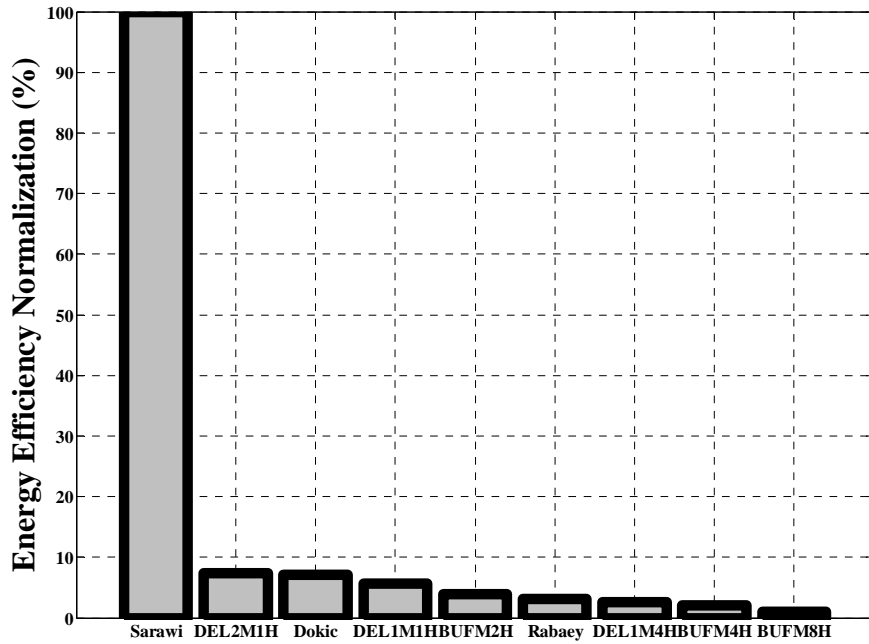


Fig. 3.8. Normalization of energy efficiency with standard cells and HDCs.



## 3.2 Proposed Hysteresis Delay Cell

### 3.2.1 Formulation

The reason of the longest delay value and most area and energy efficiency in Sarawi HDC is the wide hysteresis voltage width and creeping rise/fall time of output. As shown in Fig. 3.5, when the input voltage of HDC decreases from  $V_{DD}$  to  $V_{-}$  in the reverse switching path, the currents of the transistors,  $mp2$ ,  $mn2$  and  $mp1$ , are the same [25] as follows.

$$I_{mp2} = I_{mn2} = I_{mp1} \quad (3-5)$$

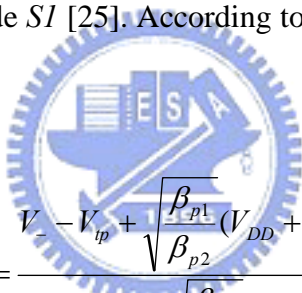
Thus, we may rewrite (3-5) as

$$\frac{1}{2}\beta_{p2}(V_- - V_{S1} - V_{tp})^2 = \frac{1}{2}\beta_{n2}(V_- - V_{tn})^2 = \frac{1}{2}\beta_{p1}(V_{S1} - V_{DD} - V_{tp})^2 \quad (3-6)$$

where  $\beta_m$  is the transconductance of transistor  $m$  labeled in Fig. 3.6.  $V_{tn}$  and  $V_{tp}$  is threshold voltage of NMOS and PMOS, respectively. Based on the left hand side of (3-6), we have

$$V_- = \frac{V_{S1} + V_{tp} + \sqrt{\frac{\beta_{n2}}{\beta_{p2}} * V_{tn}}}{1 + \sqrt{\frac{\beta_{n2}}{\beta_{p2}}}} \quad (3-7)$$

where  $V_{S1}$  is the voltage in node  $S1$  [25]. According to the right hand side in (3-6), the  $V_{S1}$  is expressed as



$$V_{S1} = \frac{V_- - V_{tp} + \sqrt{\frac{\beta_{p1}}{\beta_{p2}}}(V_{DD} + V_{tp})}{1 + \sqrt{\frac{\beta_{p2}}{\beta_{p1}}}} \quad (3-8)$$

Substituting this result in (3-8) into (3-7), we summarize the expression as

$$V_- = \frac{R_p V_{DD} + 2R_p V_{tp} + R(1 + R_p)V_{tn}}{RR_p + R_p + R} \quad (3-9)$$

where  $R_p = \sqrt{\beta_{p1}/\beta_{p2}}$  and  $R = \sqrt{\beta_{n2}/\beta_{p2}}$ . If  $V_{tp} = -V_{tn}$ , we may rewrite (3-9) as

$$V_- = \frac{R_p V_{DD} + (RR_p - 2R_p + R)V_{tn}}{RR_p + R_p + R} \quad (3-10)$$

The same analysis as forward switching with  $mp2$ ,  $mn2$  and  $mn1$  is as follows [25]. When a low value signal is applied to  $V_{IN}$ ,  $V_{OUT}$  goes high.  $V_{OUT}$  would switch from high to low until  $V_{IN}$  increases into  $V_+$ . In the forward switching path, the relationship of the currents between transistors  $mp2$ ,  $mn2$  and  $mn1$  can be written as

$$I_{mn2} = I_{mp2} = I_{mn1} \quad (3-11)$$

$$\frac{1}{2}\beta_{n2}(V_+ - V_{S2} - V_{tn})^2 = \frac{1}{2}\beta_{p2}(V_+ - V_{DD} - V_{tp})^2 = \frac{1}{2}\beta_{n1}(V_{S2} - V_{tn})^2 \quad (3-12)$$

From (3-12), we have the forward switching point as similar as (3-9).

$$V_+ = \frac{(R_n + 1)V_{DD} + (R_n + 1)V_{tp} + 2RR_nV_{tn}}{RR_n + R_n + 1} \quad (3-13)$$

where  $R_n = \sqrt{\beta_{n1}/\beta_{n2}}$ . When  $V_{tp} = -V_{tn}$ , (3-13) is expressed as

$$V_+ = \frac{(R_n + 1)V_{DD} + (2RR_n - R_n - 1)V_{tn}}{RR_n + R_n + 1} \quad (3-14)$$

The switching points,  $V_+$  and  $V_-$ , of Sarawi HDC can be calculated by (3-10) and (3-14) with  $R = R_p = R_n = 1$ , leading to  $V_- = V_{DD}/3$ ,  $V_+ = V_{DD} * 2/3$  and  $V_{hw} = V_{DD}/3$  [25].

Consequently, based on (3-10) and (3-14), we substitute  $R=1$  in these equations. The switching points  $V_-$  and  $V_+$  can be rewritten as

$$V_- = \frac{V_{tn} + R_p(V_{DD} - V_{tn})}{2R_p + 1} \quad (3-15)$$

$$V_+ = \frac{V_{DD} - V_{tn} + R_n(V_{DD} + V_{tn})}{2R_n + 1} \quad (3-16)$$



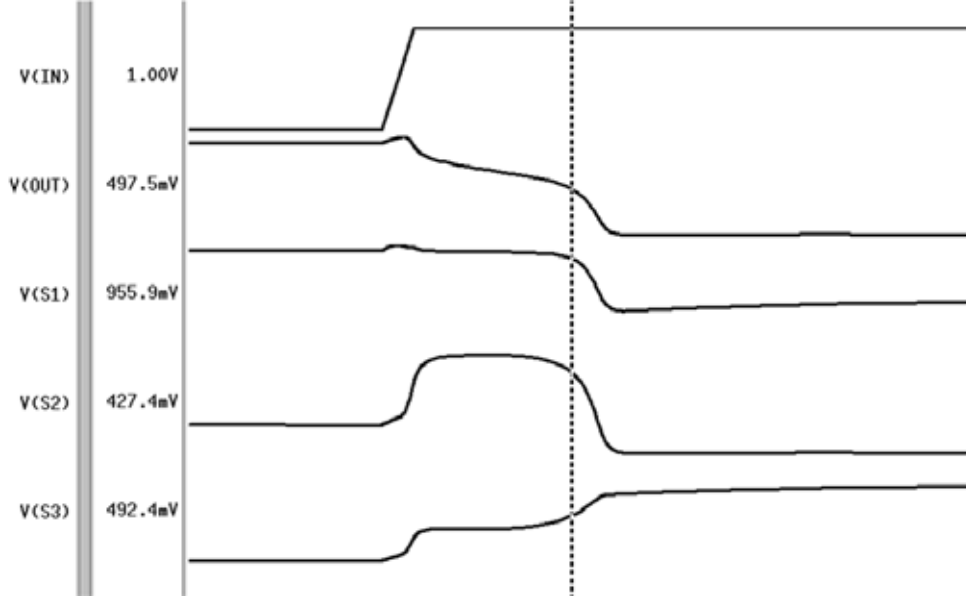


Fig. 3.9. Transition response of Sarawi HDC.

The rise time  $T_{RISE}$  and fall time  $T_{FALL}$  of the HDC circuits contribute the most delay in the hysteresis phenomenon. As shown in Fig. 3.9, the transition time of the HDC dominates the overall propagation delay.

Assume the output capacitance  $C_{OUT}$  is voltage independent. The fall time  $T_{FALL}$  consists of three intervals. The first part  $t_{f1}$  is the time interval of  $V_{OUT}$  from  $(0.9*V_{DD})$  to  $(V_{DD} - V_m)$  and  $m_n2$  is operated in saturation region, resulting in increasing voltage of node  $S2$ . The model is expressed as

$$C_{OUT} \frac{dV_{OUT}}{dt} = -\frac{\beta_{n2}}{2} (V_{DD} - V_m)^2 \quad (3-17)$$

Taking the integration, we obtain

$$C_{OUT} \int_{0.9V_{DD}}^{V_{DD}-V_m} dV_{OUT} = -\frac{\beta_{n2}}{2} (V_{DD} - V_m)^2 \int_0^{t_{f1}} dt \quad (3-18)$$

Therefore, (3-19) is summarized as

$$t_{f1} = \frac{2C_{OUT}(V_{in} - 0.1V_{DD})}{\beta_{n2}(V_{DD} - V_{in})^2} \quad (3-19)$$

The second part  $t_{f2}$  is the time interval when  $mn2$  is in linear region. In this interval,  $V_{OUT}$  drops from  $(V_{DD} - V_{in})$  to  $(0.5*V_{DD})$  and then turns on  $mn1$ , which is shown as

$$C_{OUT} \frac{dV_{OUT}}{dt} = -\frac{\beta_{n2}}{2} (2(V_{DD} - V_{in})V_{OUT} - V_{OUT}^2) \quad (3-20)$$

$$C_{OUT} \int_{V_{DD}-V_{in}}^{0.5V_{DD}} \frac{dV_{OUT}}{2((V_{DD} - V_{in})V_{OUT} - V_{OUT}^2)} = -\frac{\beta_{n2}}{2} \int_0^{t_{f2}} dt \quad (3-21)$$

$$t_{f2} = \frac{C_{OUT}}{\beta_{n2}(V_{DD} - V_{in})} \ln \frac{3V_{DD} - 4V_{in}}{V_{DD}} \quad (3-22)$$

The other part  $t_{f3}$  is the time interval when  $mn1$  and  $mn2$  are both in linear region. In the discharging interval,  $V_{OUT}$  drops from  $(0.5*V_{DD})$  to  $(0.1*V_{DD})$  through  $mn1$  and  $mn2$ . We can find that

$$C_{OUT} \frac{dV_{OUT}}{dt} = -\frac{\beta_N}{2} (2(V_{DD} - V_{in})V_{OUT} - V_{OUT}^2) \quad (3-23)$$

$$C_{OUT} \int_{0.5V_{DD}}^{0.1V_{DD}} \frac{dV_{OUT}}{2((V_{DD} - V_{in})V_{OUT} - V_{OUT}^2)} = -\frac{\beta_N}{2} \int_0^{t_{f3}} dt \quad (3-24)$$

$$t_{f3} = \frac{C_{OUT}}{\beta_N(V_{DD} - V_{in})} \ln \frac{19V_{DD} - 20V_{in}}{3V_{DD} - 4V_{in}} \quad (3-25)$$

where the  $\beta_N$  is the equivalent transconductance of combination of  $mn1$  and  $mn2$ .

$$\beta_N = \frac{1}{\frac{1}{\beta_{n1}} + \frac{1}{\beta_{n2}}} \quad (3-26)$$

Consequently, the fall time  $T_{FALL}$  is the summation of  $t_{f1}$ ,  $t_{f2}$  and  $t_{f3}$ . From (3-19), (3-22) and (3-24), we may rewrite the expression as

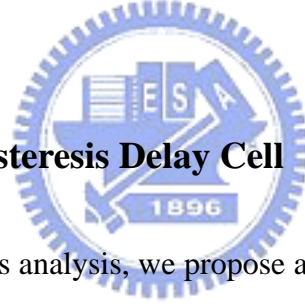
$$T_{FALL} = \frac{C_{OUT}}{\beta_{n2}(V_{DD} - V_m)} \left( \frac{2V_m - 0.2V_{DD}}{V_{DD} - V_m} + \ln \frac{3V_{DD} - 4V_m}{V_{DD}} + \frac{\beta_{n2}}{\beta_N} \ln \frac{19V_{DD} - 20V_m}{3V_{DD} - 4V_m} \right) \quad (3-27)$$

By the similar analysis, the rise time  $T_{RISE}$  can be obtained in (3-28).

$$T_{RISE} = \frac{C_{OUT}}{\beta_{p2}(V_{DD} + V_{tp})} \left( \frac{-2V_{tp} - 0.2V_{DD}}{V_{DD} + V_{tp}} + \ln \frac{3V_{DD} + 4V_{tp}}{V_{DD}} + \frac{\beta_{p2}}{\beta_P} \ln \frac{19V_{DD} + 20V_{tp}}{3V_{DD} + 4V_{tp}} \right) \quad (3-28)$$

where  $\beta_P$  is the equivalent transconductance of  $mp1$  and  $mp2$ .

Based on (3-27) and (3-28), the rise time  $T_{RISE}$  and fall time  $T_{FALL}$  are inverse proportional to the transconductances  $\beta_{n2}$ ,  $\beta_N$ ,  $\beta_{p2}$  and  $\beta_P$ . Thus, we can control the propagation delay of HDC by different  $\beta_{n2}$ ,  $\beta_N$ ,  $\beta_{p2}$  and  $\beta_P$ .



### 3.2.2 Delay Tunable Hysteresis Delay Cell

According to the previous analysis, we propose a seven stage delay tunable HDC based on the original low power HDC architecture as shown in Fig. 3.10. The sizing of transistors in Fig. 3.10 is listed in Table 3.3. These delay stages control the fall time  $T_{FALL}$  by the discharge transconductance in the proposed HDC. With different codeword, the proposed circuits perform different values in the propagation delay. The simulation results of delay value and power consumption is shown in Fig. 3.11 and Fig. 3.12, respectively. The proposed HDC can achieve 0.78 ps delay resolution, and the delay range is from 1.643 ns to 1.742 ns with the fine delay linearity which guarantees a monotonic delay behavior when the control word increases. The delay value is several hundreds times cell delay of one minimum size inverter and the power consumption is below 2.2  $\mu$ W in each codeword.

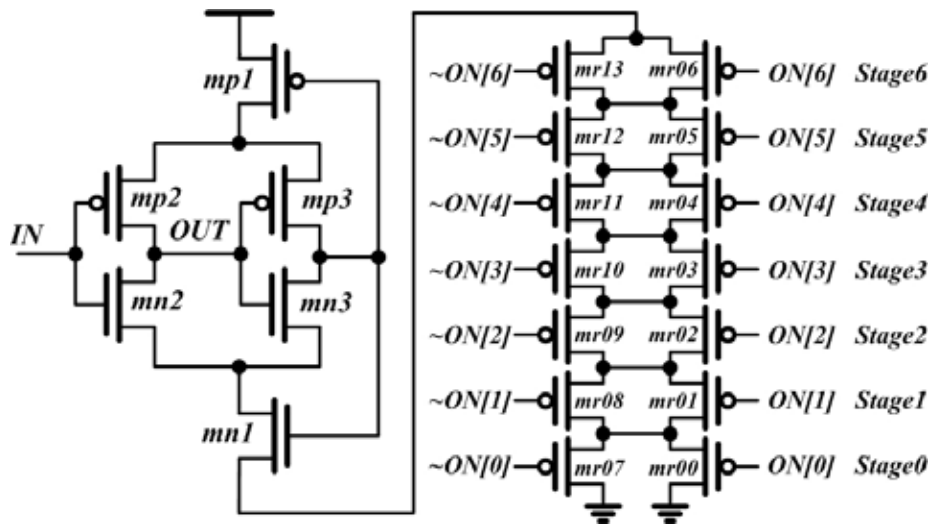


Fig. 3.10. Proposed delay tunable HDC.

Table 3.3. Transistor size of proposed delay tunable HDC.

Transistor	mp1	mp2	mp3	mn1	mn2	mn3	mr00	mr01	mr02	mr03
W/L ( $\mu\text{m}/\mu\text{m}$ )	$\frac{0.36}{0.08}$	$\frac{0.36}{0.08}$	$\frac{0.36}{0.08}$	$\frac{0.36}{0.08}$	$\frac{0.24}{0.08}$	$\frac{0.24}{0.08}$	$\frac{0.23}{0.16}$	$\frac{0.22}{0.16}$	$\frac{0.20}{0.16}$	$\frac{0.17}{0.16}$
Transistor	mr04	mr05	mr06	mr07	mr08	mr09	mr10	mr11	mr12	mr13
W/L ( $\mu\text{m}/\mu\text{m}$ )	$\frac{0.14}{0.16}$	$\frac{0.16}{0.24}$	$\frac{0.11}{0.24}$	$\frac{0.12}{0.08}$	$\frac{0.12}{0.08}$	$\frac{0.12}{0.08}$	$\frac{0.12}{0.08}$	$\frac{0.12}{0.08}$	$\frac{0.12}{0.08}$	$\frac{0.12}{0.08}$

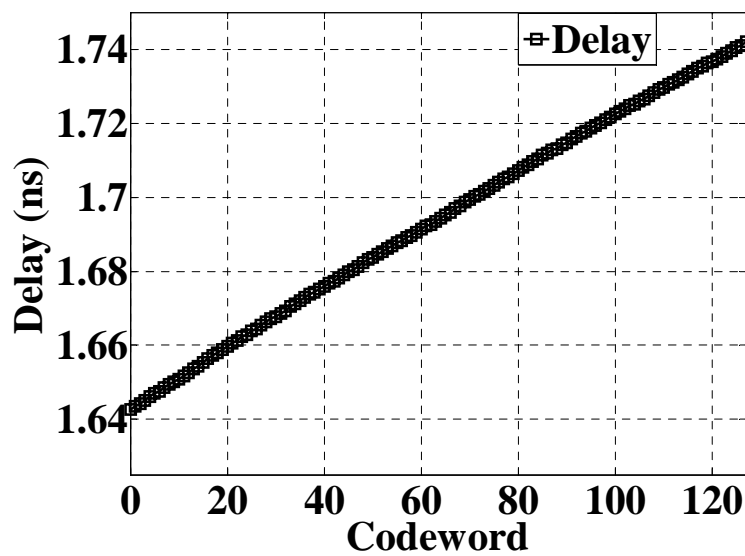


Fig. 3.11. Delay of the proposed delay tunable HDC.

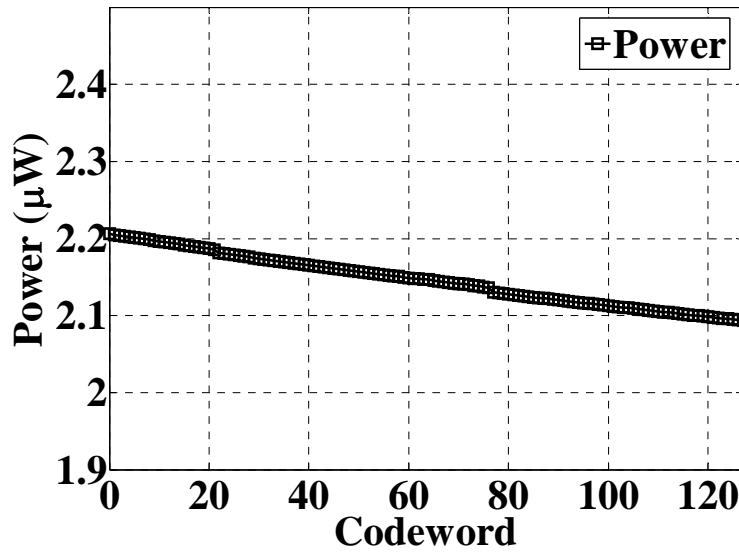


Fig. 3.12. Power of the proposed delay tunable HDC.

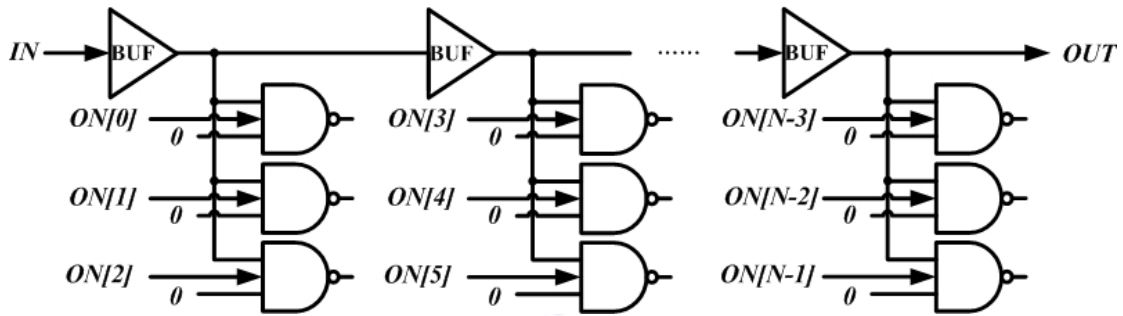


Fig. 3.13. Cascading BUF and DCV.

Table 3.4 illustrates the features and comparisons with proposed delay tunable HDC and the most commonly-used cascading BUF and DCV approach [10] which is depicted in Fig. 3.13. The proposed delay tunable HDC with similar propagation delay and controllable range can perform better performance in resolution, power and area. The delay resolution improves the DCO frequency tuning step and covers every desired delay value in DCO. The 98.4 % power reduction and 92.8 % area reduction implies both dynamic and static power saving, resulting in better area efficiency and energy efficiency on clock generator.

Table 3.4. Comparison of cascading BUF and DCV to delay tunable HDC.

Transistor	Delay (ns)	Controllable Range (ps)	Resolution (ps)	Power ( $\mu$ W)	Area ( $\mu\text{m}^2$ )
Cascading BUF & DCV	1.86	67.7	2.26	133	6.048
Proposed Delay Tunable HDC	1.64	99.4	0.78	2.2	0.437

### 3.3 Proposed HDC-Based Digitally Controlled Oscillator

By the above proposed delay tunable HDC, we design a 5 MHz low power all-HDC-based DCO as shown in Fig. 3.14. The proposed DCO is partitioned into two tuning stages. The 1st tuning stage composed of HDC1 extends the controllable range of DCO. The 2nd tuning stage, cascading HDC2, is for the delay resolution improvement. Because the targeted frequency is 5 MHz, the total delay of HDCs in 2nd stage has less than 200 ns under any PVT conditions. Furthermore, the delay controllable range in 2nd tuning stage must cover the delay resolution of 1st tuning stage, avoiding false lock in PFTCG, ADPLL [5-8] or ADDLL [14] applications.

The delay resolution of 1st tuning stage is summation the summation of propagation delay from low to high ( $T_{PLH}$ ) and propagation delay from high to low ( $T_{PHL}$ ) of HDC1. The architecture of HDC1 is illustrated in Fig. 3.15. Based on the Sarawi HDC, we apply an extra transistor  $mp4$  as the header. The *ENABLE* signal is used for isolating the redundant delay elements in the closed loop and saving the power consumption. Generally, the dynamic power  $P_{dym}$  in the 1st tuning stage is expressed as

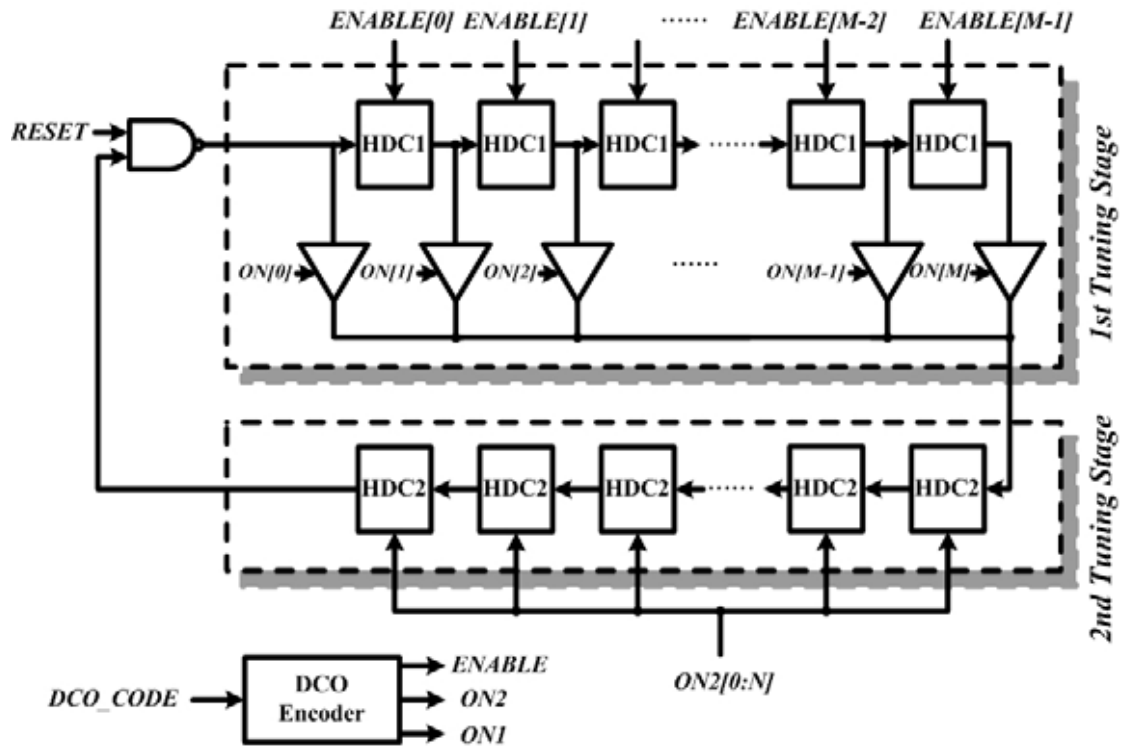


Fig. 3.14. Architecture of the proposed HDC-based DCO.

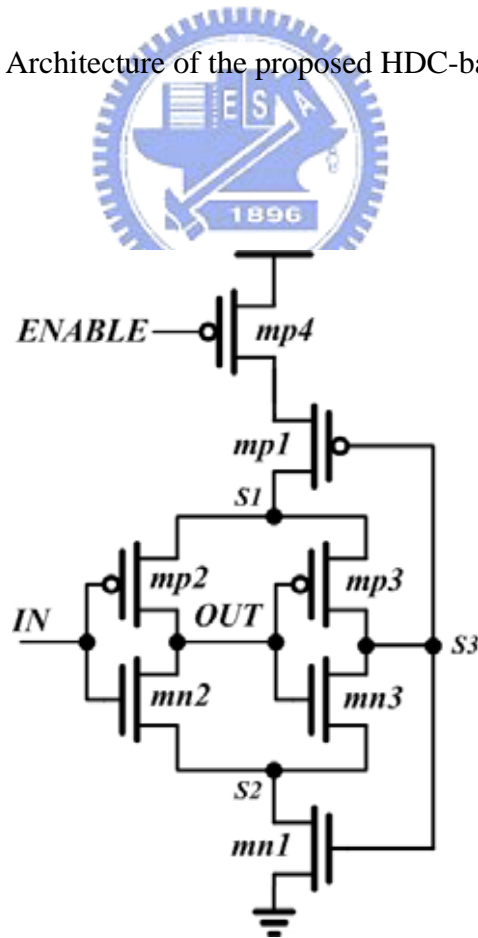


Fig. 3.15. Delay element of the 1st tuning stage.

$$P_{dym} = C_L V_{DD}^2 f \quad (3-29)$$

where  $C_L$  is the overall loading capacitance and  $f$  is the circuit operating frequency. When we don't disable the redundant delay elements outside the closed loop in 1st tuning stage of DCO, the power becomes

$$P_{dym} = C_L V_{DD}^2 f = (M * C_{cell}) V_{DD}^2 \frac{1}{N * T_D} = \frac{M}{N} * \frac{C_{cell} V_{DD}^2}{T_D} \quad (3-30)$$

where  $M$  is the total number of HDC1,  $N$  is the number of HDC1 in the closed loop,  $C_{cell}$  and  $T_D$  are the capacitance and delay value of one HDC1, respectively. When the *ENABLE* signal turns off the redundant delay, the dynamic power is written as

$$P_{dym} = (N * C_{cell}) V_{DD}^2 \frac{1}{N * T_D} = \frac{C_{cell} V_{DD}^2}{T_D} \quad (3-31)$$

The dynamic power with disabled redundant elements is  $N/M$  times of the power with unblocked the elements. In other words, the power consumption with disabled redundant elements is independent of  $N$ . It also means that the 1st tuning stage power consumption is fixed as shown as (3-31) whatever DCO operating frequency is. Consequently, the power and delay characteristics of HDC1 imply the overall 1st tuning stage power performance.

The 2nd stage delay element HDC2 is the same as the proposed delay tunable HDC in Section 3.2, which provides both delay resolution and delay offset. For covering the delay resolution of 1st tuning stage, the 2nd tuning stage must have enough controllable range. Thus, the number of 2nd tuning stage element increases to 64. Table 3.5 summarizes the control code length, controllable range and delay resolution of the 5 MHZ all-HDC-based DCO.



For hundred-MHz DCO application, we can apply the same DCO architecture as shown in Fig. 3.14. The HDC1 in the 1st tuning stage can be changed with the small delay value cells, like AND logic-gate cells, for decreasing the delay value and increasing the operating frequency. The 2nd tuning stage still applies the cascading delay tunable HDC for preserving the resolution. Table 3.6 shows the simulation results of modified 200 MHz HDC-based DCO. The code length is 14 bits with 6 bits in 1st tuning stage and 8 bits in 2nd tuning stage. The LSB delay resolution is still 0.78 ps.

Table 3.5. Controllable range and delay resolution of 5 MHz HDC-based DCO.

	1st Tuning Stage	2nd Tuning Stage
Code Length (bits)	7	13
Range (ns)	412.201	6.362
Resolution (ps)	3246	0.78

Table 3.6. Controllable range and delay resolution of 200 MHz HDC-based DCO.

	1st Tuning Stage	2nd Tuning Stage
Code Length (bits)	6	8
Range (ns)	10.09	0.199
Resolution (ps)	160	0.78

### 3.4 Simulation Result

Based on the low power and high delay resolution for WBAN application [3], the proposed HDC-based DCO is verified and implemented in the standard process 90 nm high threshold voltage (SPHVT) CMOS technology in both 5 MHz and 200 MHz operating frequencies. The power consumption is 2.6  $\mu$ W at 5 MHz and 14.3  $\mu$ W at 200 MHz under 1.0 V supply voltage, respectively. The reason for larger power at 200 MHz than 5 MHz DCO is the poor energy efficiency of standard AND logic-gates in 1st tuning stage. The LSB resolutions of both DCOs with delay tunable HDC are 0.78 ps. The designed 5 MHz DCO requires 20 bits control word length and the range of operating frequency is from 1.9 MHz (526.3 ns) to 9.4 MHz (106.8 ns). The other DCO, operating at 200 MHz, has 14 bits codeword and operating range is from 69.8 MHz (14.3 ns) to 249.4 MHz (4.01 ns) with 0.78 ps delay resolution.

Note that it is easy to extend the controllable range of these DCOs by changing the HDC numbers or using other small delay cells in the 1st tuning stage. In order to fine-tune the delay resolution, the equivalent transconductance of delay tunable HDCs in the 2nd tuning stage can be easily controlled as well.

Table 3.7 lists the overall comparison to the state-of-the-art DCOs. The proposed DCO has the least power dissipation compared with other designs, and also achieves high delay resolution. As a result, the proposed HDC-based DCO indeed has the benefits of better resolution, operation range and delay linearity for low power applications.

Table 3.7. Performance comparison of DCO.

Performance Indices	Proposed DCO	Proposed DCO	TCAS2'07 [11]	JSSC'05 [9]	ISQED'02 [20]	ISCAS'06 [8]	JSSC'04 [6]
Process	90nm	90nm	90nm	0.18 $\mu$ m	0.13 $\mu$ m	0.13 $\mu$ m	0.35 $\mu$ m
Supply Voltage (V)	1	1	1	1.8	1.65	1.2	3
DCO Control Word Length	20	14	15	5	8	8	7
Operation Range (MHz)	1.9~9.4	70~249	191~952	413~485	150	200~750	152~366
LSB Resolution (ps)	0.78	0.78	1.47	2	40	N/A	10~150
Power Consumption	2.6 $\mu$ W (@5MHz)	14.3 $\mu$ W (@200MHz)	140 $\mu$ W (@200MHz)	170~340 $\mu$ W (Static only)	*0.5mW (@150MHz)	*0.85mW (@560MHz)	*12mW (@366MHz)

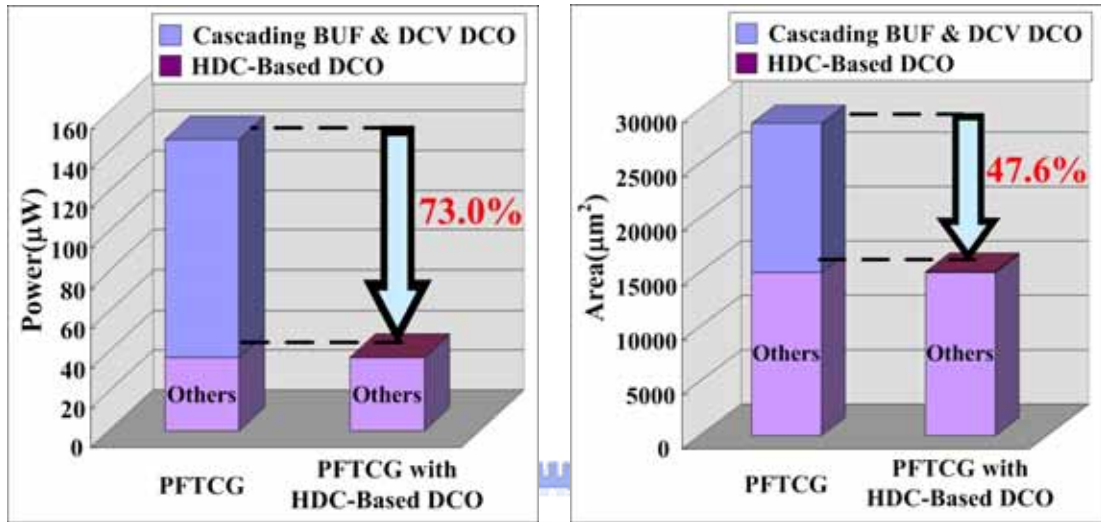
\*Power consumption estimated from 50% of ADPLL



### 3.5 Summary

In this chapter, we introduce a low power, small area and high delay resolution DCO by the HDC. Compared with the standard cells, the proposed HDC not only has the low power and small area feature, but also achieves high delay resolution with linearity. With the aid of the proposed HDC, the 5 MHz DCO has 0.78 ps LSB delay resolution and only consumes 2.6  $\mu$ W under 1.0 V. Another proposed design of 200 MHz DCO can provide 0.78 ps resolution and 14.3  $\mu$ W under 1.0 V supply voltage in the standard process 90 nm CMOS technologies, which consumes the least power dissipation of the state-of-the-art DCO.

As a result, this work enables 97.6 % power reduction and 99.6 % area reduction in comparison with the previous DCO in Chapter 2 under 1.0 V. In terms of the all-digital PFTCG, the overall power and area reduction are 73.0 % and 47.6 %, respectively.



(a)

(b)

Fig. 3.16. PFTCG comparison (a) power (b) area.

## ***CHAPTER 4***

### ***PVT Tolerance Clock Generator***

In general, the quartz crystal oscillator is the familiar solution to reference clock source in communication systems. For WBAN applications, the requirements of clock source are low power, low cost and small area, especially in WSN. Although the quartz crystal oscillator can provide good stability under different PVT variations, the milli-watt power consumption [26], large area and extra board component bonding are the fatal disadvantages. The additional board components also result in the difficulty in system integrations and increase the manufacturing cost. The silicon micro-electro-mechanical systems (MEMS) [12] have been proposed to replace the quartz crystal oscillator. But, the extra CMOS processes, wafer level packaging technologies and long manufacturing duration increase the cost and the time to market (TTM) as well. Furthermore, in the quartz crystal oscillators and MEMS approaches, the frequency accuracy would decay when operating time increases. The generated clock is incapable of calibrating by the system.

In system level, the ring oscillator seems to a better solution to chip integration, power budget and area. A 7 MHz ring oscillator [13] has been proposed by adding a band-gap voltage regulator, temperature and process compensation circuits and a

comparator. However, the operational amplifiers in voltage regulator and comparator consume large power. Moreover, when the CMOS technology scales to the next advanced generation, the PVT variations become worse as shown in Fig. 1.4. The violent frequency variation rate of 5 MHz ring oscillator is about 60 % under the worst case PVT corners.

For the low power and integrable clock source applications, such as WBAN, the design challenge is against the serious PVT variations. In the following sections, we describe a new methodology to generate a stable and low power clock source under any PVT variations. The proposed design also has frequency tuning capability to fine-tune the clock frequency and avoid the frequency drift in the long service life. The design specification is 5 MHz which is as same as the PFTCG reference clock source.

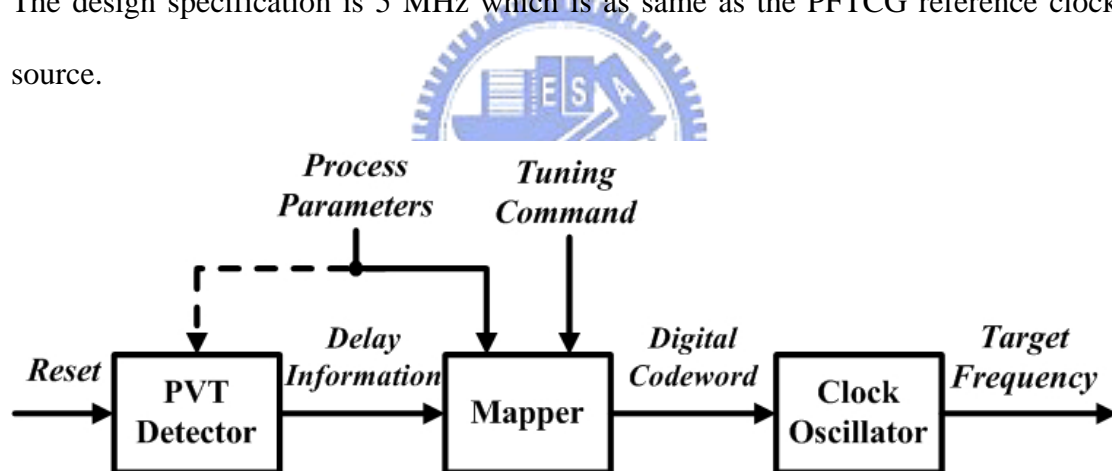


Fig. 4.1. Architecture of the proposed PVT tolerance clock generator.

## 4.1 Architecture

The proposed PVT tolerance clock generator is shown in Fig. 4.1. It is composed of three blocks, including PVT detector, mapper and clock oscillator. The PVT detector can extract the delay information from different PVT conditions. The mapper

transfers the information to a digital codeword for calibrating the PVT variations. The clock oscillator receives the digital codeword from mapper and generates the target frequency clock.

The process parameters are provided by the standard chip testing procedure and stored in one time programming (OTP) devices to calibrate the process variation. The process calibration behavior can be executed on the mapper, or on both PVT detector and mapper. The frequency tuning command feedbacks from system frequency recovery loop for fine-tuning the clock frequency [2].

## 4.2 Circuit Designs

### 4.2.1 PVT Detector



The PVT detector senses the PVT conditions and transfers the response of delay information to a digital code. The delay information is extracted by delay cells which have different PVT sensitivities. Suppose there are two different delay cells in the PVT detector, namely the reference delay cells and variable delay cells. These two delay cells with different PVT sensitivities result in different delay variation rates under different PVT conditions. The PVT detector can observe the relative delay variation between the reference cells and variable cells by the delay ratio

$$R(P, V, T) = \frac{D_{VAR}(P, V, T)}{D_{REF}(P, V, T)} \quad (4-1)$$

where  $D_{VAR}(P,V,T)$  is the delay of a variable cell and  $D_{REF}(P,V,T)$  is the delay of a reference cell. Both delay values depend on the PVT conditions, so the delay ratio  $R(P,V,T)$  is a function of PVT as well.

Fig. 4.2 shows the delay ratio of variable cell (ND4M0H\_L) to reference cell (BUFM8H) versus absolute delay under different PVT corners. The ND4M0H\_L is a ND4M0H cell with another ND4M0H in the output loading. The ND4M0H and BUFM8H cells are both standard cells in UMC 90 nm SPHVT technology. The cell delay value results from a step input. In Fig. 4.2, the x-axis is the delay ratio  $R(P,V,T)$  and the y-axis is the absolute delay value. The three groups of data are the simulation results on the three process corners (FF, TT, SS). Each group covers different simulating voltage (0.9 V ~ 1.1 V) and temperature (0 ~ 125 °C) variations.

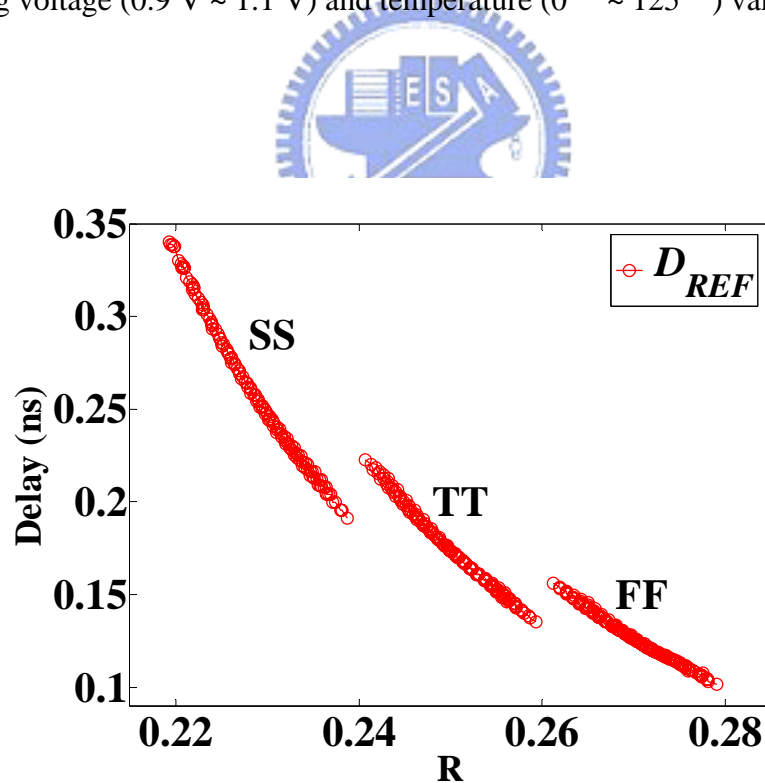


Fig. 4.2. Delay ratio of ND4M0H\_L to BUFM8H.



The relation between delay ratio and absolute delay value of reference cell can be modeled a one-to-one mapping function under fixed process variation. Thus, the delay variation under certain process condition is approximated to a second order curve, which is written as

$$D_{Model}(P,V,T) = \hat{D}_{REF}(P,V,T) = a * R(P,V,T)^2 + b * R(P,V,T) + c \quad (4-2)$$

where  $a$ ,  $b$  and  $c$  represents the process variation coefficients. These process variation parameters can be obtained and stored from the chip testing procedure. Then, the second order modeling error is expressed as

$$E_{Model} = abs\left(\frac{D_{Model}(P,V,T) - D_{REF}(P,V,T)}{D_{REF}(P,V,T)}\right) \quad (4-3)$$

The simulation results of the second order modeling curves are shown in Fig. 4.3 (a). The modeling error is limited by the PVT sensitivity between the reference cells and variable cells, which is the vibrations of the curves as shown in Fig. 4.3 (b). The maximum modeling error is about 2.05 % as shown in Fig. 4.4.

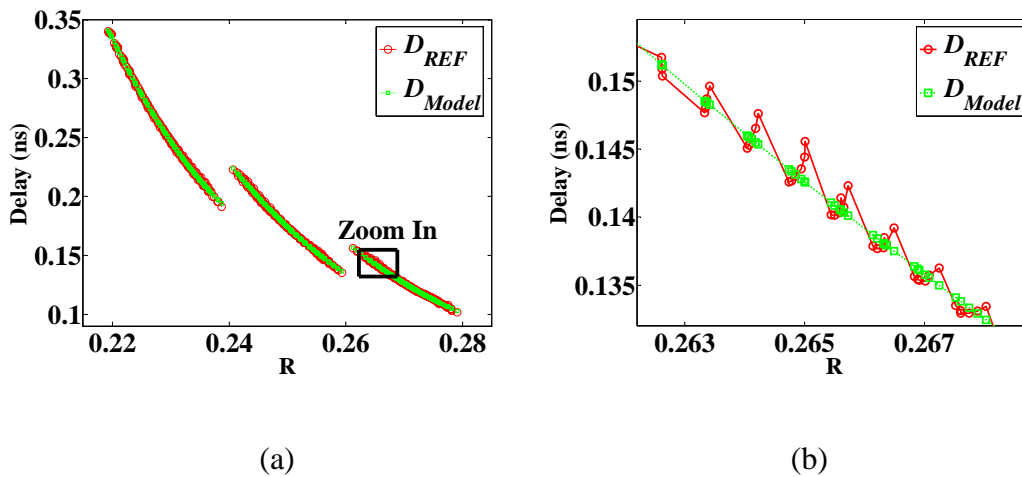


Fig. 4.3. Second order modeling curve of delay value.

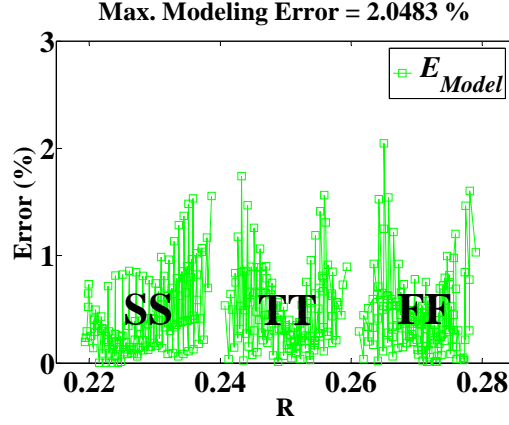


Fig. 4.4. Second order modeling error.

For implementation, we have to partition the delay ratio into several intervals and map the digital codeword of delay ratio into the real delay value. In the  $i$ -th delay ratio region, we can map these delay ratios into a delay value  $D_{Partition,i}$ .

$$D_{Model,i,MAX} = a * R_{i,MIN}^2 + b * R_{i,MIN} + c \quad (4-4)$$

$$D_{Model,i,MIN} = a * R_{i,MAX}^2 + b * R_{i,MAX} + c \quad (4-5)$$

$$D_{Partition,i} = \frac{D_{Model,i,MAX} + D_{Model,i,MIN}}{2} = a * R_{Partition,i}^2 + b * R_{Partition,i} + c \quad (4-6)$$

where  $R_{i,MIN}$  is the minimum delay ratio in the  $i$ -th region and  $R_{i,MAX}$  is the maximum delay ratio in the  $i$ -th region.  $D_{Model,i,MAX}$  and  $D_{Model,i,MIN}$  are the maximum and minimum modeling delay in the  $i$ -th delay ratio region, respectively.  $R_{Partition,i}$  is the corresponding delay ratio in the  $i$ -th region. The frequency error after partition is written as

$$E_{Partition,i} = abs\left(\frac{D_{Partition,i} - D_{REF}(P,V,T)}{D_{REF}(P,V,T)}\right) \quad (4-7)$$

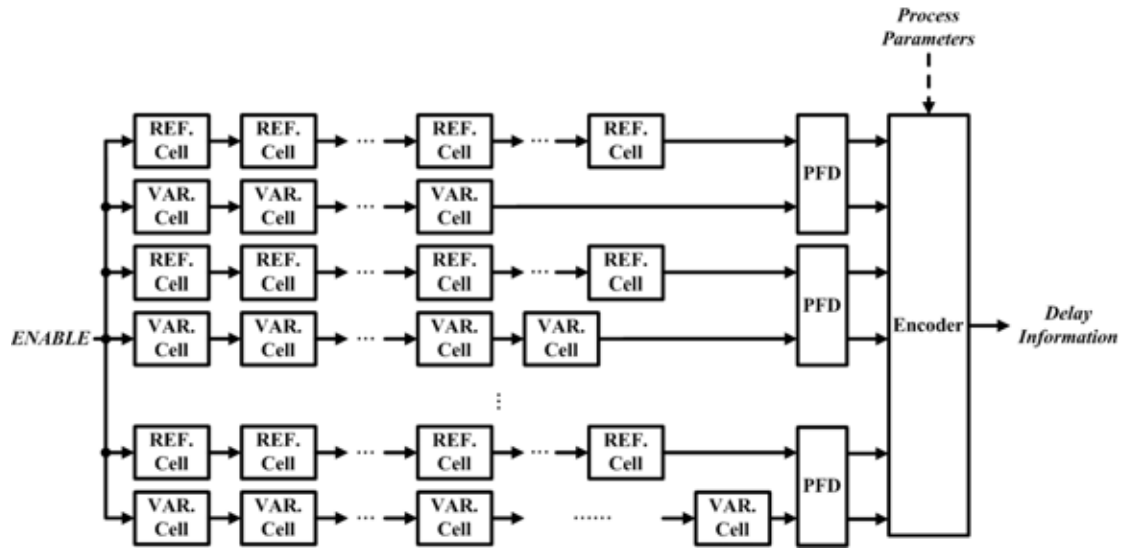


Fig. 4.5. Architecture of the proposed PVT detector.

Fig. 4.5 describes the proposed architecture of PVT detector. The PFD is the phase frequency detector whose architecture is the same as Fig. 2.4. Each PFD connects the delay lines composed of reference cell and variable cell with different cell numbers. In the beginning, a step input (*ENABLE*) triggers the PVT detector. Then, the step pulse passes through the two type delay lines. Each PFD detects the lead or lag between each pairs of delay lines and generates the up and down signals. According to these up and down signals, we can estimate the delay ratio of single reference cell to single variable cell.

The function of encoder includes the transformation from up/down signals into divided delay ratio and the mapping from the delay ratio to the real delay time of reference cell with the process variation parameters as (4-6). Fig. 4.6 shows the simulation results of PVT detector partition curves. In a certain separated delay ratio region, all delay ratio values are mapped into a fixed delay. Fig. 4.7 shows the partition error under different PVT conditions. The maximum partition error is about 2.03 %.

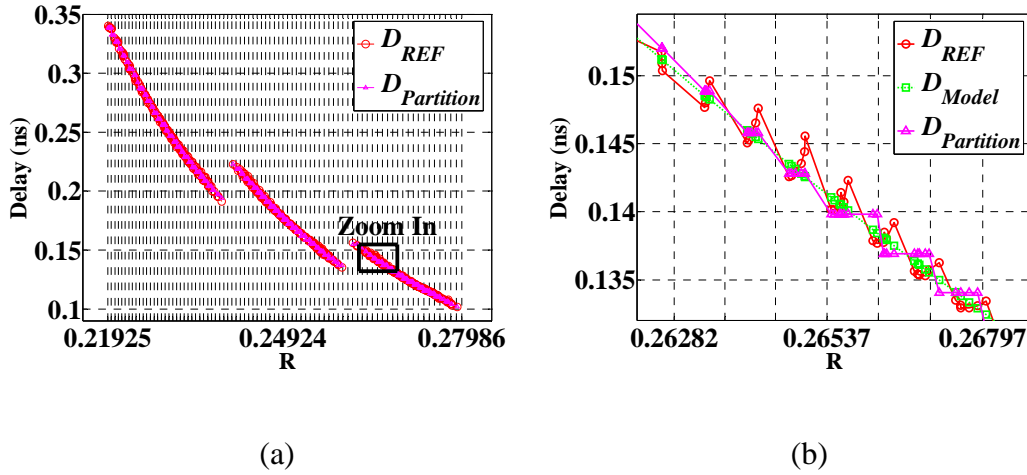


Fig. 4.6. Second order partition curve of delay value.

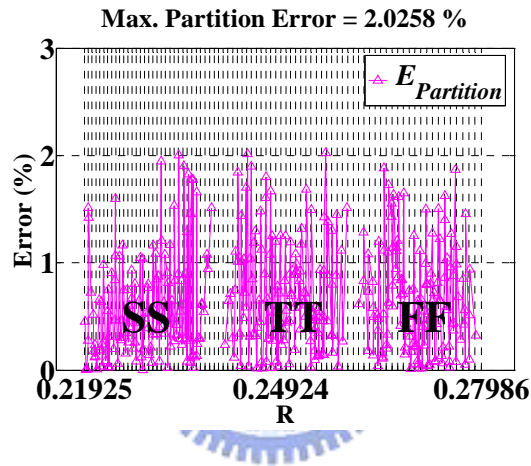


Fig. 4.7. Second order partition error.

## 4.2.2 Mapper

The mapper transfers the PVT information, the absolute delay value of reference cell, to a digital control code of the oscillator with the process variation parameters. That is to say, the mapper converges the 3-dimension variations, including process, voltage and temperature, towards 1-dimension oscillator codeword. By (4-2), the delay of an oscillator cell can be modeled as

$$D_{OSC}(P,V,T) = M(\hat{D}_{REF}(P,V,T)) = a' * R(P,V,T)^2 + b' * R(P,V,T) + c' \quad (4-8)$$

where  $M$  is the mapping function of the mapper, and  $a'$ ,  $b'$  and  $c'$  are the modified process variation coefficients. Then, the clock oscillator cell number in the closed loop is express as

$$N_{OSC} = \frac{1}{f * D_{OSC}(P,V,T)} = a'' * R(P,V,T)^2 + b'' * R(P,V,T) + c'' \quad (4-9)$$

where  $f$  is the target frequency of the generated clock from clock oscillator. The oscillator control codeword can be regarded as clock oscillator cell numbers with an offset in  $c''$ . Hence, we summarize (4-9) as

$$Codeword_{OSC}(P,V,T) = a'' * R(P,V,T)^2 + b'' * R(P,V,T) + c'' \quad (4-10)$$

Thus, we can combine the encoder in PVT detector into the mapper. In other words, the mapper would transfer the delay ratio from PVT detector to oscillator codeword by modified process variation parameters as

$$Codeword_{Mapping} = a'' * R_{Partition}^2 + b'' * R_{Partition} + c''' \quad (4-11)$$

The mapper also receives the frequency tuning command from system frequency recovery loop [2]. The frequency tuning command controls the oscillator codeword and fine-tunes the output clock frequency.

$$Codeword_{Mapping} = a'' * R_{Partition}^2 + b'' * R_{Partition} + c''' + d \quad (4-12)$$

where  $d$  is the tuning step from frequency tuning command. The process parameters  $a''$ ,  $b''$  and  $c'''$  can be acquired and stored in the OTP devices. The error after mapper is written as

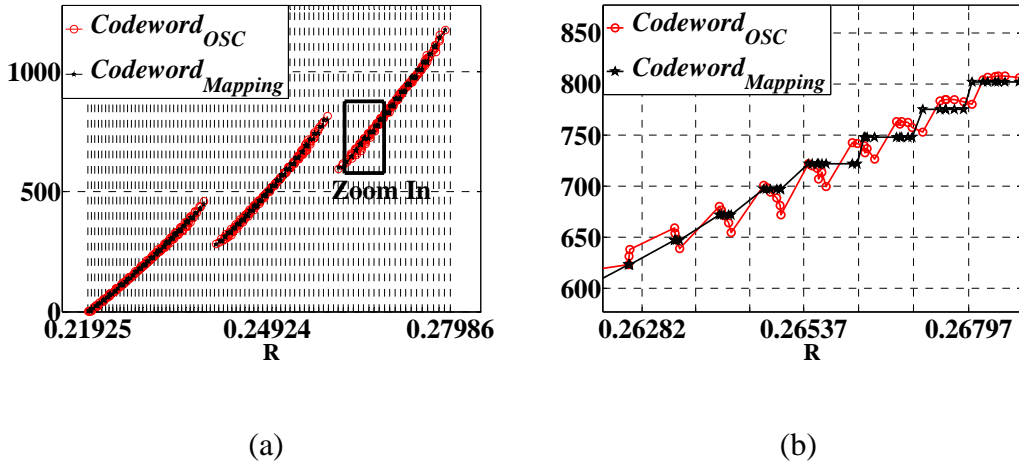


Fig. 4.8. Second order mapping curve of oscillator codeword.

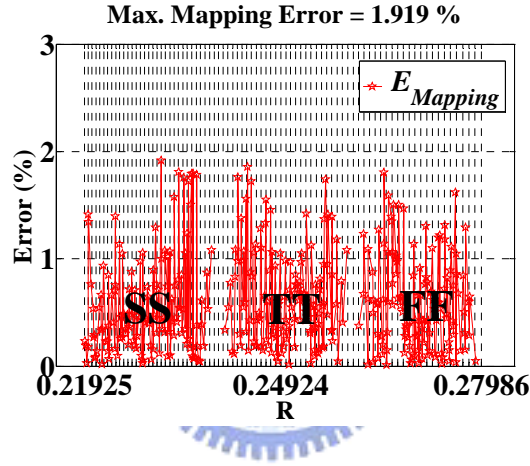


Fig. 4.9. Second order mapping error.

$$E_{Mapping} = \text{abs}\left(\frac{\text{Codeword}_{Mapping} - \text{Codeword}_{OSC}(P, V, T)}{\text{Codeword}_{OSC}(P, V, T)}\right) \quad (4-13)$$

There are simulations of mapping curves in Fig. 4.8. The oscillator cell, CKINVM8H, is also the standard cell in UMC 90 nm SPHVT. The trends of mapping curves are invert with the partition curves as shown in Fig. 4.6. Larger delay ratio implies less delay of oscillator cells, resulting in larger oscillator cell numbers for the same clock period. Fig. 4.9 depicts the mapping error under different PVT conditions. The mapping error depends on the partition error, the PVT sensitivity of oscillator cell and clock oscillator resolution. The maximum mapping error is about 1.92 %.

### 4.2.3 Clock Oscillator

In clock oscillator, the PVT sensitivity and delay resolution affect the mapping error. The degree of vibrations in mapping curve, as shown in Fig. 4.8(b), results from the PVT sensitivity of oscillator cells. Less PVT sensitivity would increase the stability of clock oscillator and reduce the mapping error in mapper. High delay resolution is also required for improving the frequency accuracy in clock oscillator.

The block diagram of clock oscillator is shown in Fig. 4.10. There is a delay line composed of oscillator cells. The path selectors are constructed from several tri-state buffers [5]. The oscillator encoder encodes the oscillator codeword ( $Codeword_{Mapping}$ ) to the control signals ( $ON$ ) to tri-state buffer. The output in tri-state buffers is divided by 8 and generates the target 5 MHz clock. Although these tri-state inverters bring out extra delay uncertainty in the clock oscillator under different PVT conditions, the delay uncertainty can be ignored in the long delay line. As a result, the non-ideal effect can be also calibrated by the process parameters and frequency tuning command as (4-12).

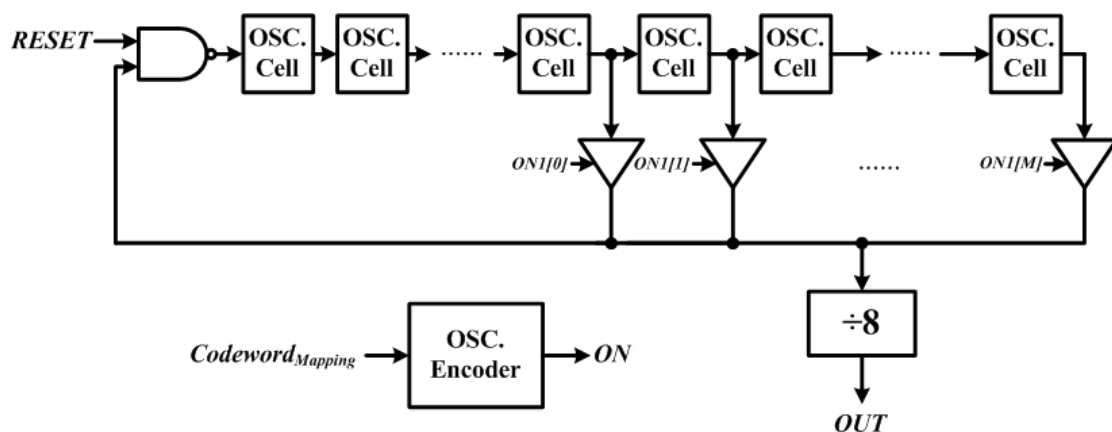


Fig. 4.10. Architecture of the proposed clock oscillator.

### 4.3 Simulation Result

The simulation results of the proposed PVT tolerance clock generator are shown in the above sections. The PVT detector applies 84 pairs delay detector circuits and estimates the delay ratio of a reference cell (ND4M0H\_L) to a variable cell (BUFM8H). The 84 variable cell delay lines have 292 ~ 375 cell numbers, respectively. The reference cell delay lines all have 82 cell numbers. We separate the delay ratio into 83 intervals. The maximum partition error is 2.03 %. After the mapper and clock oscillator, the frequency error of output clock is less than 1.92 % without frequency tuning command. Then, the frequency error can be reduced to 20 ppm by system frequency calibration loop [2].

The response time of proposed PVT tolerance clock is less than 100 ns due to the delay lines in PVT detector. After system reset, the PVT detector is triggered once and then records the present PVT information until the frequency re-tracking command from system by violent PVT variations. The power consumption of PVT detector is about 15.39 mW during the responding 100 ns. Because the PVT detector only operates once, the power can be easily reduced by extending response time. After detection, the stable power consumption of the proposed PVT tolerance clock generator is 343  $\mu$ W at 5 MHz under 1.0 V supply voltage from the clock oscillator circuits.



## 4.4 Implementation

The proposed all-digital and cell-based 5 MHz PVT tolerance clock generator is implemented with UMC 90 nm technology. Fig. 4.11 summarizes the area distribution. The PVT detector, mapper and clock oscillator occupy 89.81 %, 3.66 % and 6.52 % of overall area, respectively. The overall area is about 0.28 mm<sup>2</sup>. Fig. 4.12 is the layout view of the proposed design. The non-blocked part in Fig. 4.12 is the other design integrated with our proposed PVT tolerance clock generator.

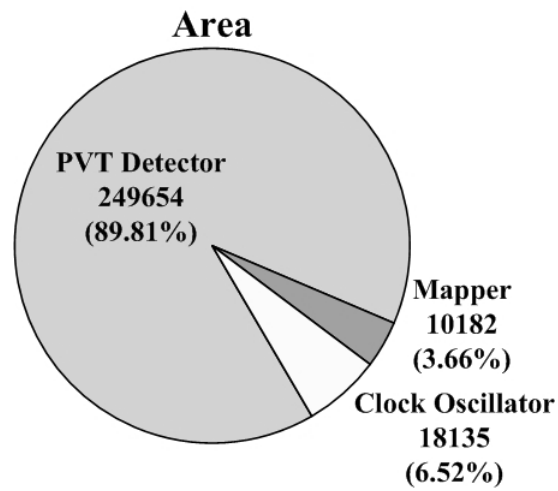


Fig. 4.11. Area distribution of PVT tolerance clock generator.

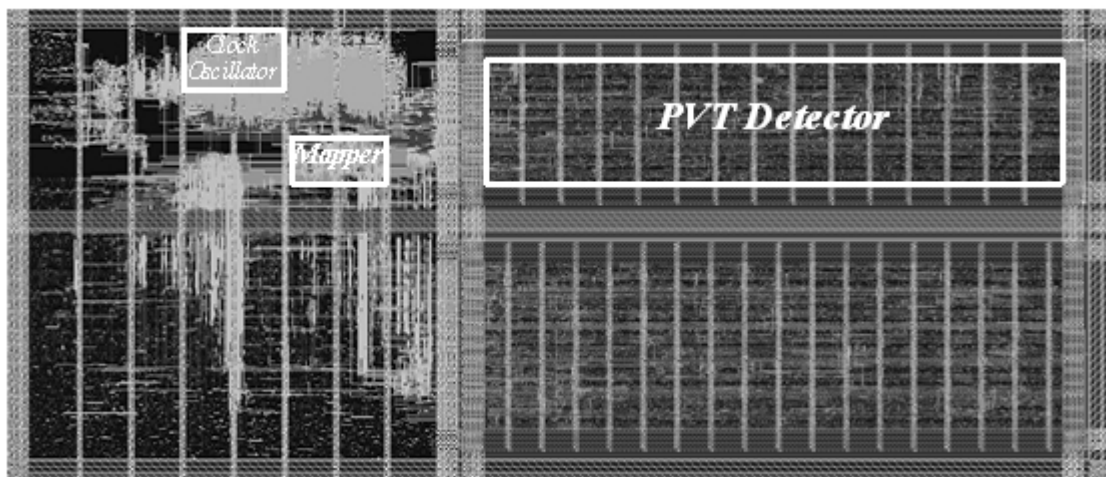


Fig. 4.12. Layout of the proposed PVT tolerance clock generator.

Table 4.1. Performance comparison of clock sources.

Performance Indices	Proposed Design	Quartz Crystal Oscillator [26]	MEMS [12]	Ring OSC. [13]
Process	90nm	With 90nm Oscillator Pad	With 0.6 $\mu$ m Compensation Circuits	0.25 $\mu$ m
Frequency (MHz)	5	5	5.5	7
Power Consumption (mW)	0.34	36.2	1.9	1.5
Area (mm <sup>2</sup> )	0.28	54.05 (Only Quartz Crystal)	2.25	1.6
Max. Frequency Error (%)	1.9 / 0.002 (FCL+DPR[2])	0.005	0.004	2.6
Frequency Tunable	Yes	No	No	No

Table 4.1 lists the comparison among different clock generators. The proposed PVT tolerance clock generator has less power consumption and less area than quartz crystal oscillator [26], MEMS [12] and ring-oscillator-based design with calibration circuits [13]. By the means of frequency tuning capability from frequency calibration loop (FCL) and DFR [2], the proposed design has similar maximum frequency error to the quartz crystal oscillator [26] and MEMS [12] approaches. When the service time increases, the frequency tuning command provides immediate frequency calibration capability to avoid frequency drift. We can always fine-tune the frequency of clock generator to enhance and hold the clock frequency accuracy.

Moreover, these two approaches, quartz crystal oscillator [26] and MEMS [12], have extra manufacturing costs and difficulties in system integration. The proposed design is all-digital and integrable with system under standard CMOS technology.

Though the ring-oscillator-based design [13] overcomes the PVT variations in 0.25  $\mu\text{m}$  with calibration circuits, the design complexity for power minimization due to band-gap voltage regulator is the major challenge in deep sub-micron CMOS process.

## 4.5 Summary

For replacing the quartz crystal oscillator, we propose a new method to design a low power, small area and high integrated clock generator with frequency tunable capability to improve the frequency accuracy. The all-digital PVT tolerance clock generator is designed with all standard cells in UMC 90 nm technology. The frequency tolerance is 1.9 % under any PVT conditions without frequency tuning command. The frequency tuning command from frequency recovery loop can enhance the frequency accuracy performance to 0.002 %. The power is 343  $\mu\text{W}$  under 1.0 V. To summarize, it is found that the proposed design achieves power and area reduction by 99.1 % and 99.5 % in comparison with the quartz crystal oscillator.

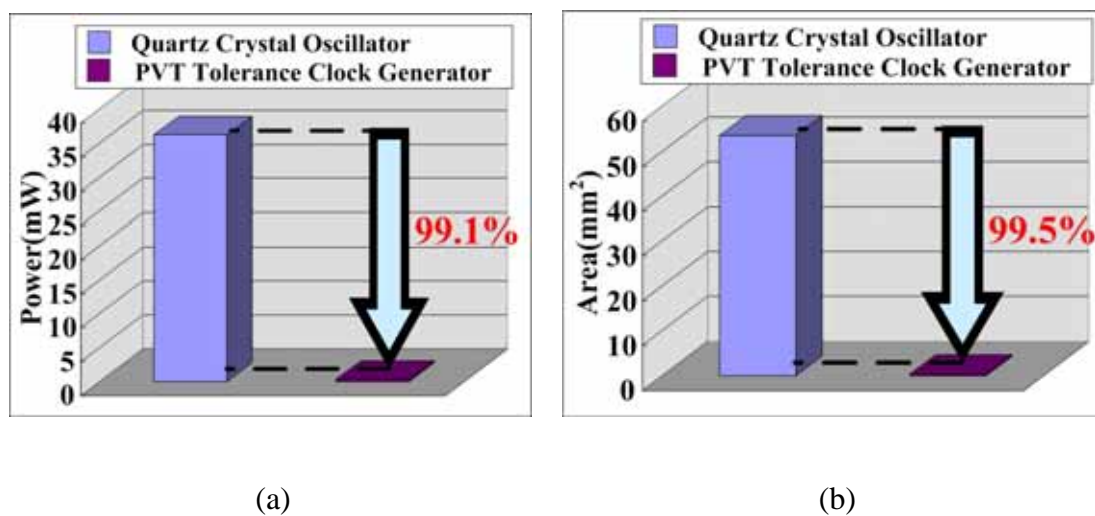


Fig. 4.13. PVT tolerance clock generator comparison (a) power (b) area.

# ***CHAPTER 5***

## ***Conclusion and Future Work***

### **5.1 Conclusion**

For wireless body area network applications, the reliability, portability and low cost are especially required. However, the ADC dominates the overall power consumption in receiver and the sampling clock frequency offset degrades the system PER performance. The all-digital PFTCG is proposed for ADC power reduction and PER performance improvement by the DPR and DFR [2]. The DPR estimates the sampling clock phase offset and directly adjusts the ADC sampling phase within the symbol rate instead of over-sampling. The DFR compensates the resulting phase error after FFT and directly tunes the ADC sampling frequency. Both methods prevent the received data from sampling clock phase and frequency interference with the aid of a PFTCG.

The proposed all-digital and cell-based PFTCG provides eight clock phases for phase selection and  $\pm 1072$  ppm frequency tuning range centered at 5 MHz. The proposed design is measured with power 145.8  $\mu$ W and 95.4  $\mu$ W at 5 MHz under 1.0

V and 0.8 V in the standard process 90 nm CMOS technology. By both DPR and PFR, the ADC power reduction, considering the PFTCG, is about 46 %.

For further power reduction on the always-turned-on clock generator, we propose a new method to design a low power DCO by the HDC. Compared with standard cells, the proposed HDC can achieve the same delay with the least area and energy. Moreover, the proposed delay tunable HDC has 0.78 ps delay resolution with fine linearity and maintains the low power feature. As a result, at 5 MHz and 200 MHz, the HDC-based DCOs consume only 2.6  $\mu$ W and 14.3  $\mu$ W under 1.0 V supply, respectively. The power and area reductions in PFTCG are 73.0 % and 47.6 %.

For replacing the large power, large area and disintegrable quartz crystal oscillator, the PVT tolerance clock generator is designed. The proposed cell-based clock generator has 1.9 % frequency tolerance under any PVT conditions without frequency tuning command. The tuning command from frequency recovery loop can enhance the frequency accuracy performance to 0.002 %. The proposed PVT tolerance clock generator is implemented with 90 nm CMOS technology and the power consumption is 343  $\mu$ W under 1.0 V. Compared with quartz crystal oscillator, we save the power and area by 99.1 % and 99.5 %, respectively.

In this thesis, we propose several designs to overcome the performance, power, area and cost challenge on clock generator for WBAN applications. The designs, including the all-digital PFTCG, low power HDC-based DCO and PVT tolerance clock generator, result in the high reliability, portability and robustness in WBAN systems. Consequently, the overall power and area reduction in WSN are 89.8 % and 88.1 %, respectively.

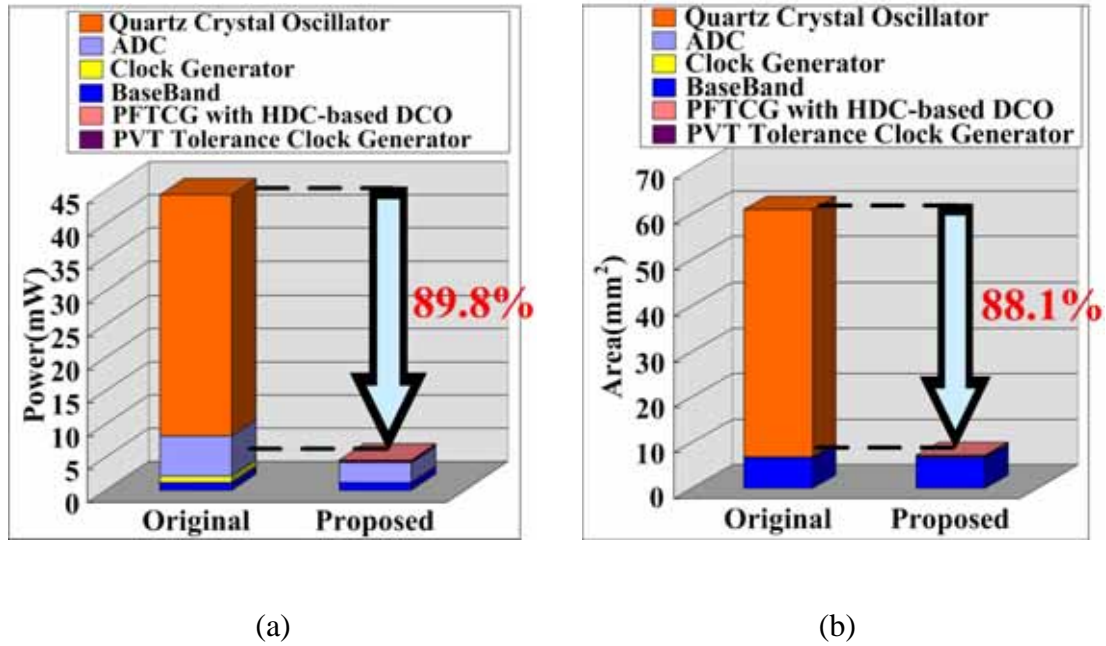


Fig. 5.1. Overall comparison (a) power (b) area.



## 5.2 Future Work

In the future, the following work is to design a modified all-digital PFTCG with the proposed low power HDC-based DCO for saving more power consumption. Then, the proposed PVT tolerance clock generator is integrated with all-digital PFTCG as well. For further area and power reduction in PVT tolerance clock generator, the delay lines architecture in PVT detector can be replaced, and the HDC-based DCO can be also integrated in the clock oscillator for power saving.

Through these integrations, we can implement an ultra low power and low cost clock generator module with phase and frequency tunable capability, which can improve the reliability and provide the competitiveness in WBAN systems.

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# 研究成果

## 研討會論文：

- [1] M.-H. Yang, J.-Y. Yu, **J.-T. Chen** and C.-Y. Lee, “A Dynamic Phase-Frequency Recovery for Power Reduction in OFDM Systems,” *International Symposium on VLSI Design, Automation and Test*, pp.107-110, April 2007.
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- [1] 李鎮宜, 游瑞元, **陳俊廷**, “數位遲滯線與其應用,” 中華民國專利申請案號 97127455, 97年7月18日。
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